

Nano-Science of Organic (Super)conductors

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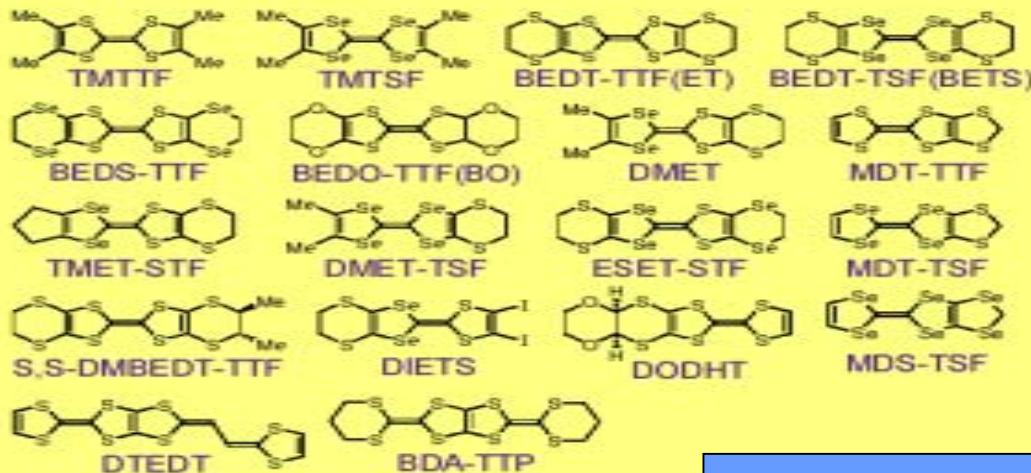


Organic Superconductors

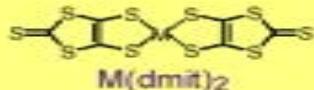
(about 120 materials since 1980)

1. Charge Transfer Complex

Donor Molecule

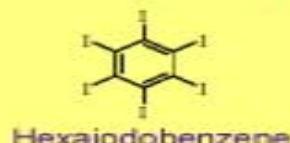
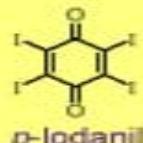


Acceptor Molecule



$\beta'-(ET)_2ICl_2$
 $T_c(\text{on set})=14.2\text{K}$
at 82 kbar

2. Single Molecule (under pressure)



Design of Organic (Super)conductors & Study of Their Physical Properties

1. Introduction

Carrier Generation & Carrier Path

On-site Coulomb Repulsion vs. Bandwidth (Mott Criterion)

Metal-Insulator or Metal-Superconductor Transition

Dimensionality Molecular Design

2. Preparation & Measurements

Crystal & Electronic (Band) Structures

Conductivity, Magnetic Susceptibility

3. 10K Class Superconductors

Electron Correlation

Anisotropic Spin Lattice

4. κ -(ET)₂Cu₂(CN)₃

Ground State

Spin-Liquid (Ambient Pressure) vs Superconductor (Uniaxial Strain)

5. Conclusion

Superconductivity is Mediated by Magnetic Interactions (non BCS)

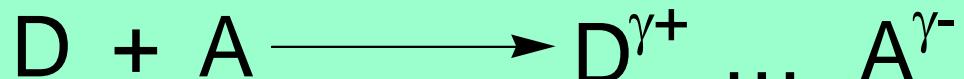
Organic Superconductor

Starting Point

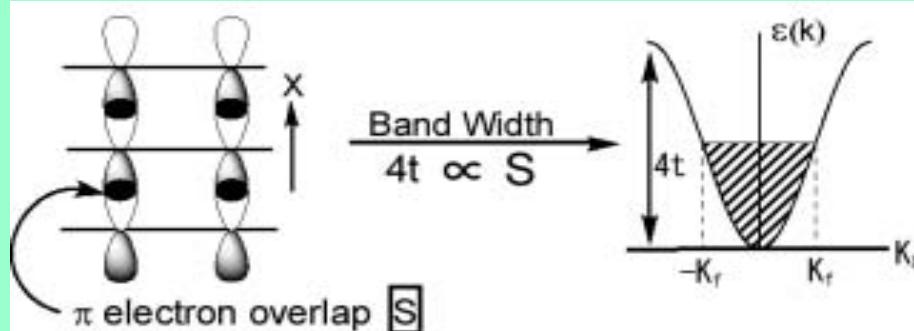
Organic Metal

Requirement i. **Generation of Carrier**
ii. **Generation of Conduction Path**

1: Charge Transfer Interaction



2: Uniform Segregated Column



$D^{1+}A^{1-}$



Metal for Inorganic

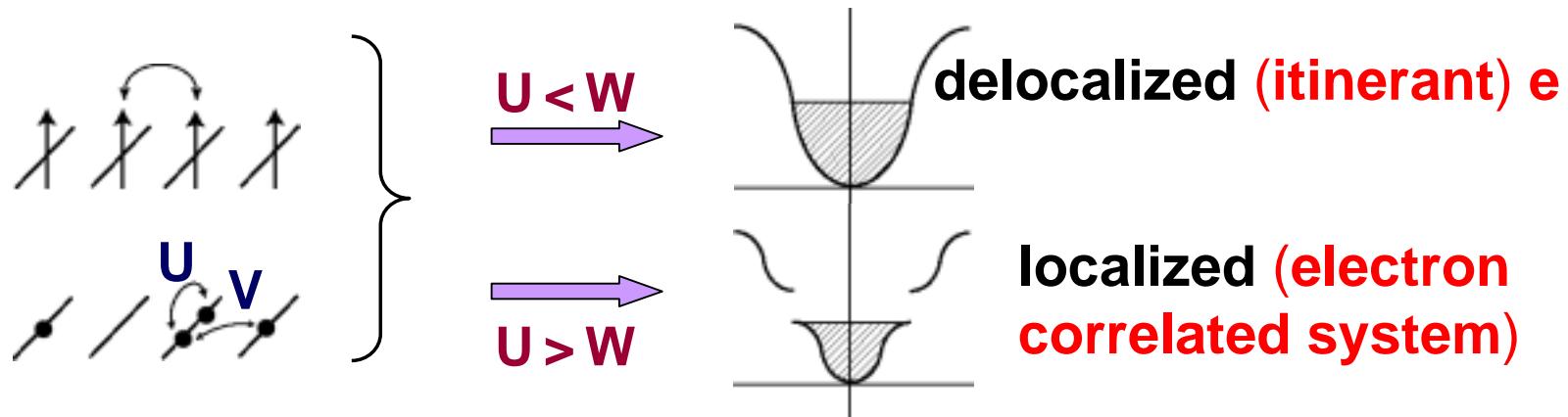
Insulator for Organic



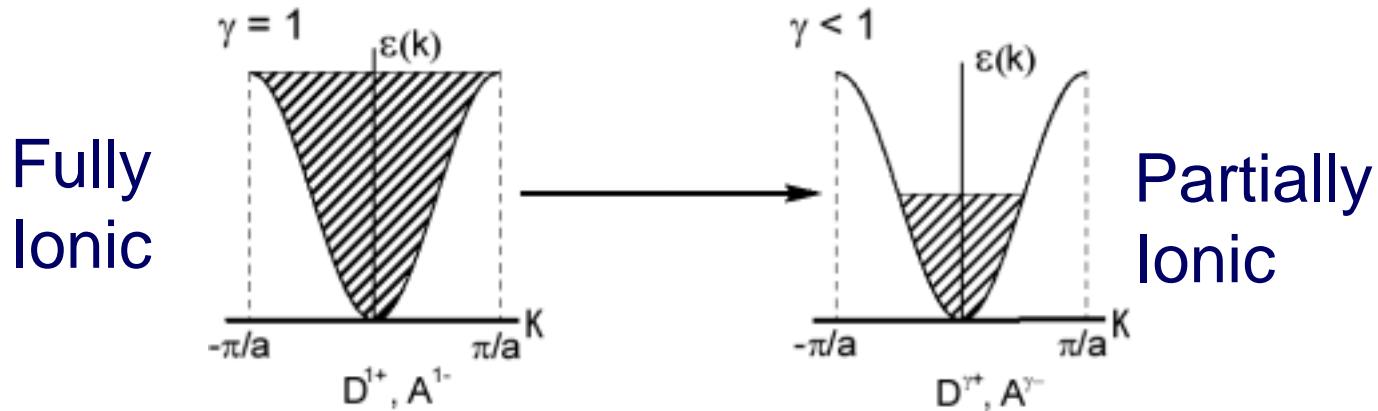
Mott Insulator

3:Mott Criterion

Organic Material \longrightarrow Bandwidth ($W = 4t$) $\lesssim U$



To overcome Mott criterion

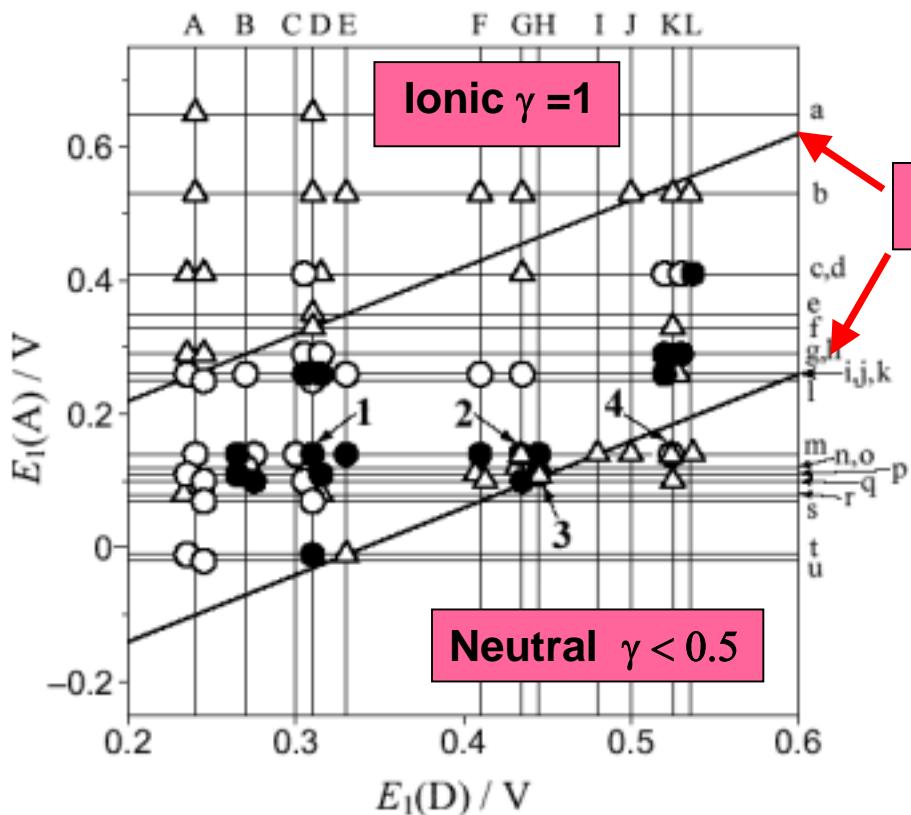


Uniform Segregated Column with Partial CT

McConnell-Hofman-Metzger Equation
Proc. Natl. Acad. Sci., USA, 53, 46(1965)

$$E_c(\gamma)/N = [(I_P - E_A)\gamma - M\gamma^2]$$

TTF•TCNQ Q-1D System



Ionic region: Mott insulator, spin-Peierls

Partial CT region: Organic Metal

Neutral region: non-linear optics

Saito, Ferraris, BCSJ, 1980

Donor

A:TTT
B:TMTTF
D:TTF
G:TMTSF
H:TSF
K:BEDT-TTF

Acceptor
b: F_4TCNQ
e: $2,5-I_2$
i:F
m:TCNQ
p: $2,5-Et_2$

: Insulator
○: Highly conducting
: Metal

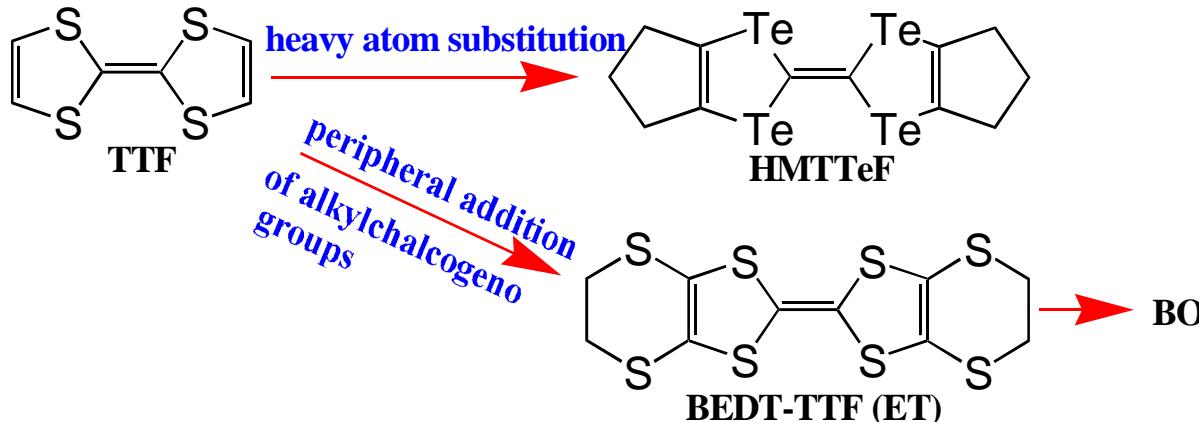
1) Partial CT state
 $-0.02 \leq \Delta E(DA) \leq +0.34$
 $0.5 \leq \gamma < 1$

2) Complex Isomerism
TMTSF•TCNQ (2)
TSF• Et_2 TCNQ (3)
ET•TCNQ (4)
→ 2D nature of ET

Modification of Dimensionality & Self-Assembling Ability

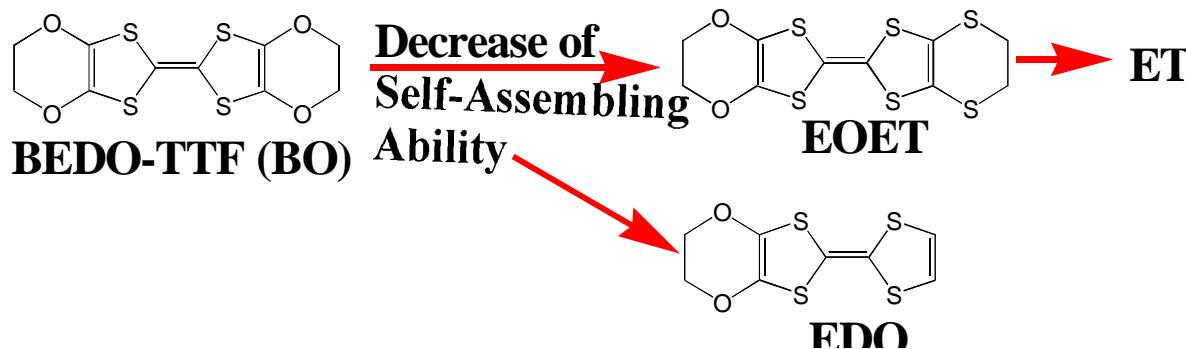
1) Increase of Dimensionality (self-assembling ability) : $t \uparrow \quad U \downarrow$

- γ becomes wide for 'metallic regime'
- Mott criterion becomes moderate
- One-D Fermi \rightarrow Two-D Fermi \rightarrow stable metal towards any disorder... BO system

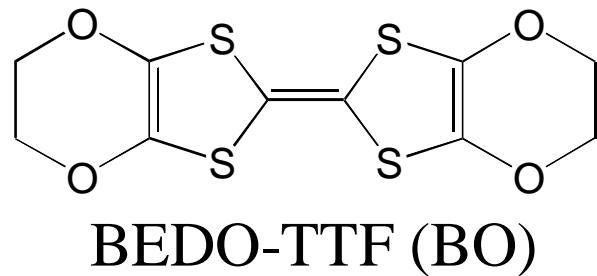
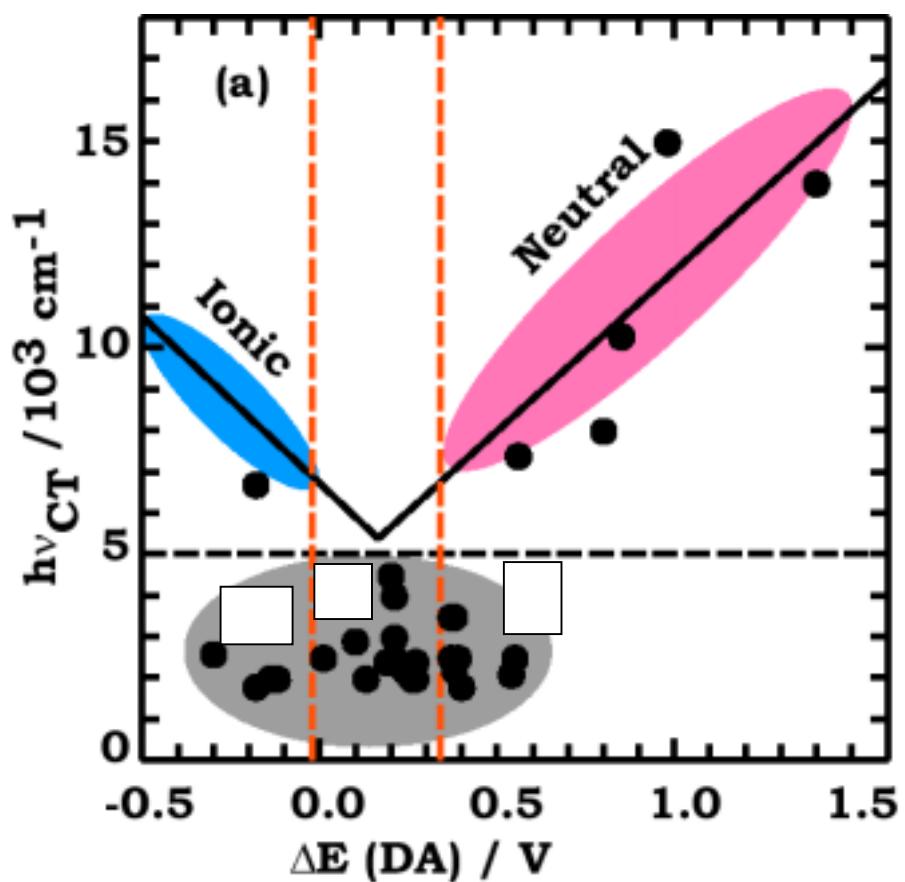


2) Decrease of Self-Assembling Ability: $t \downarrow \quad U \uparrow$

- Induce Phase Instability : New MI Phase Transition



BEDO-TTF System : Strong Self-Assembling Ability



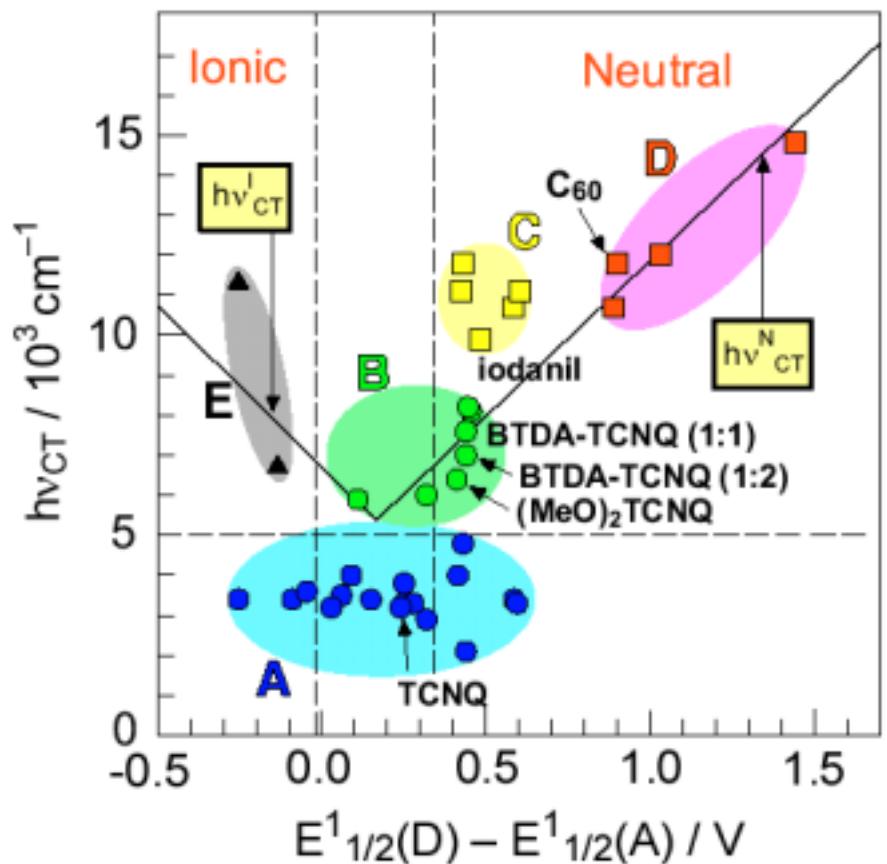
- Wide $\Delta E(\text{DA})$ for Metal
 - Stable 2D Metal
 - Strong against Disorder
(Pellet, LB & RDP Films)
- JACS, 118, 8604(1996)

D:A \neq 1:1 (D>A)

$1 > \gamma \geq 0.5$ for TTF•TCNQ

$0.5 \geq \gamma \geq 0.3$

EOET DA Complexes

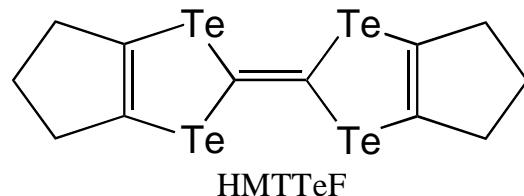
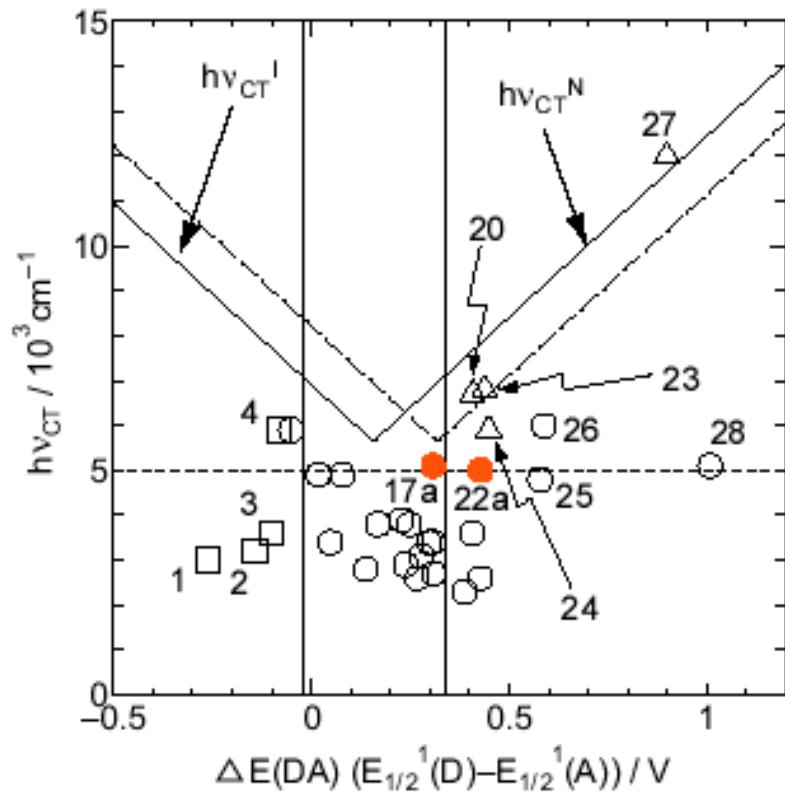


Group

- A: Partial CT & Segregated
- B: Partial CT & Alternating
- C: Clathrate
- D: Neutral & Alternating
- E: Ionic

G.Saito et al., J. Mater. Chem., 12, 1640(2002)

HMTTeF System

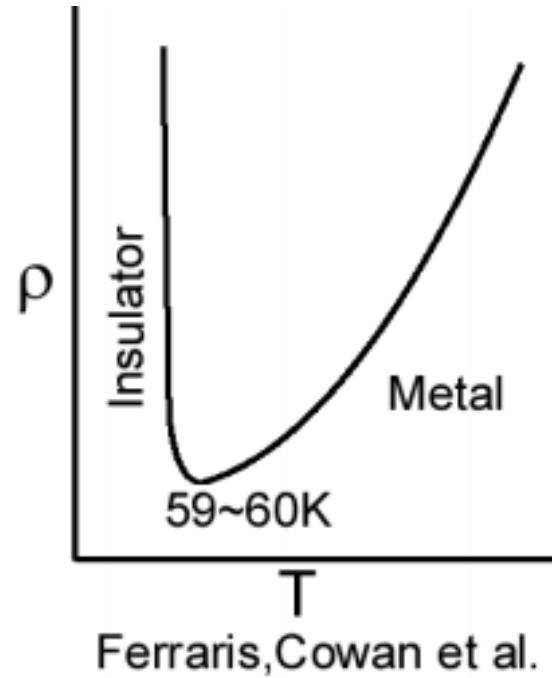
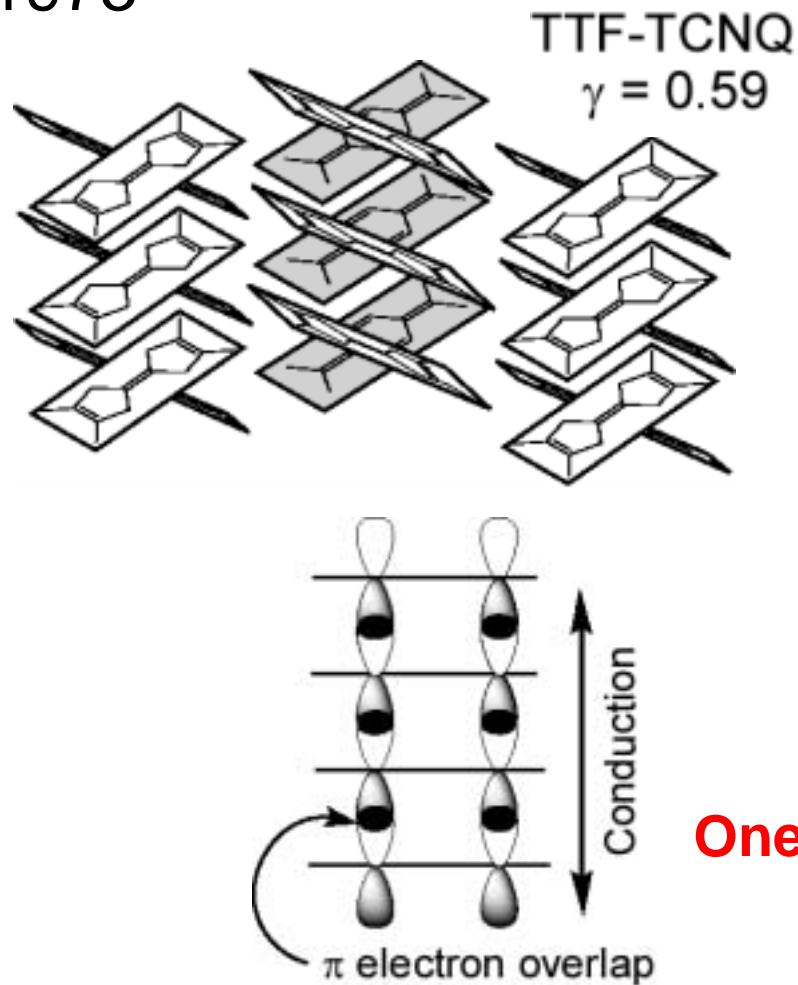


wide $\Delta E(\text{DA})$
highly conductive 10^4 S cm^{-1}

17a: HMTTeF•Et₂TCNQ•(THF)_{0.1-0.5}
22a: HMTTeF•BTDA-TCNQ(THF)_{0.1-0.5}

1. Metallic (near RT)
2. Alternating DA Stack

Organic Superconductor Starting Point Suppress the M-I Transition of Low-dimensional Metal 1973~



One-dimensional Metal

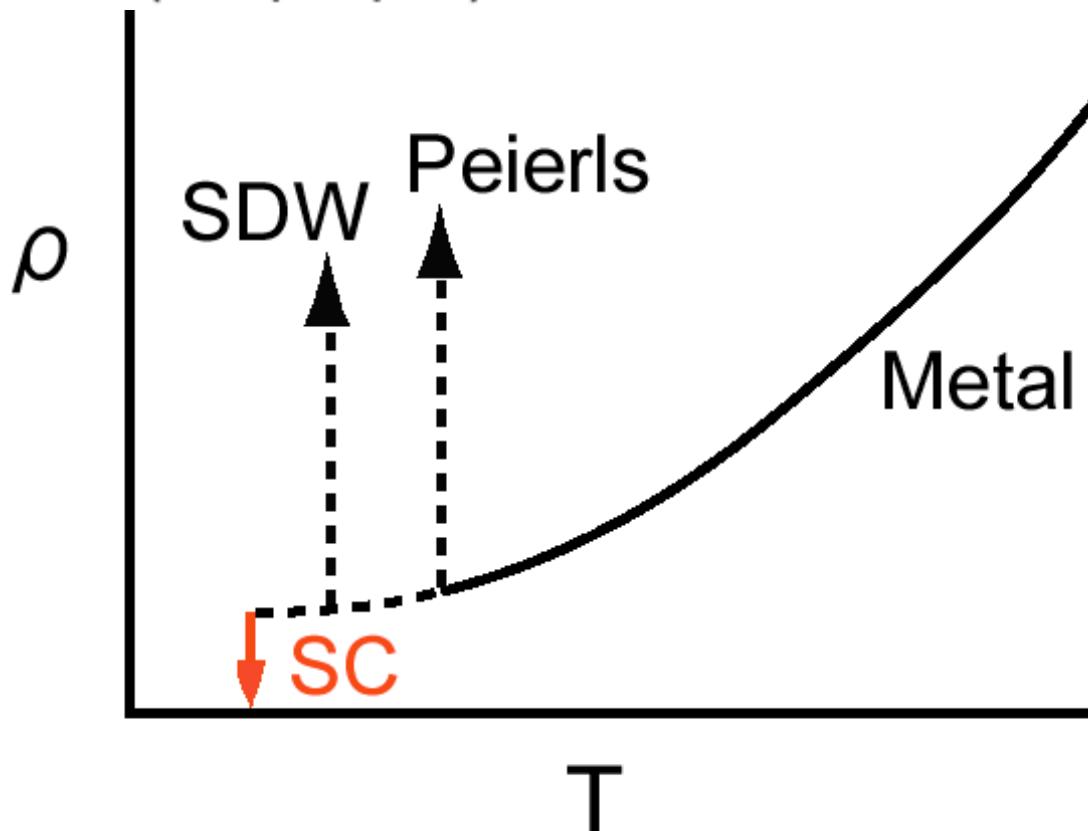
Three Low-temperature Phases of Low-dimensional Metal

1. Peierls (electron-phonon)

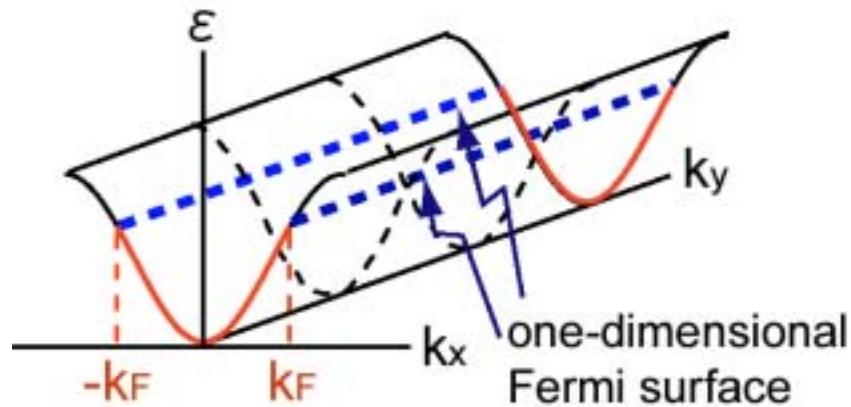
2. SDW (spin-spin)

3. SC (Cooper pair)

Organic Metal → Peierls Insulator



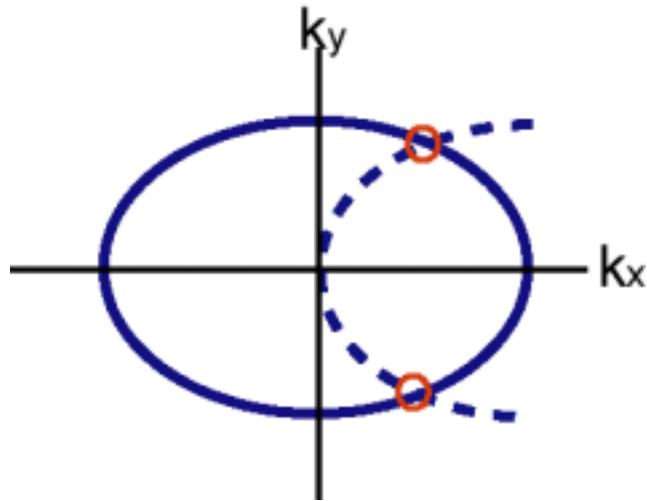
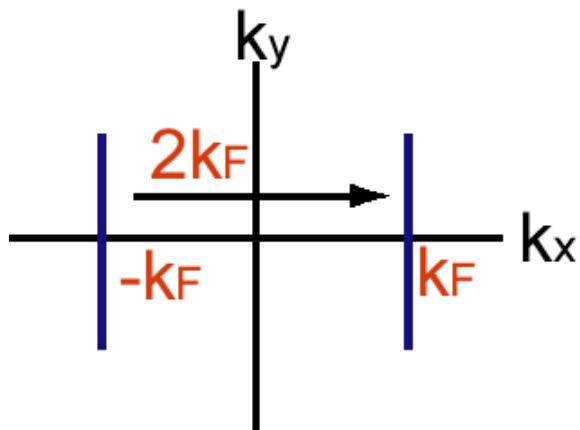
How to Suppress the Peierls Transition (in k space)



avoid $2k_F$ nesting
increase dimensionality



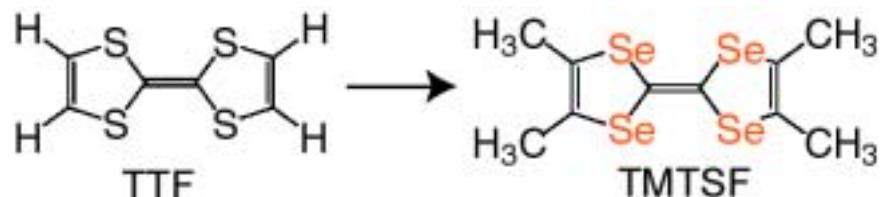
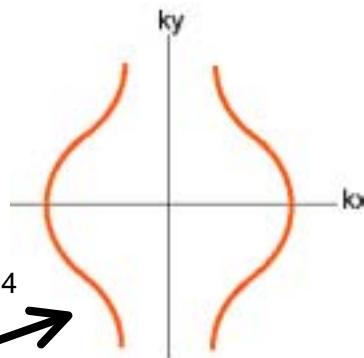
two-dimensional
Fermi surface



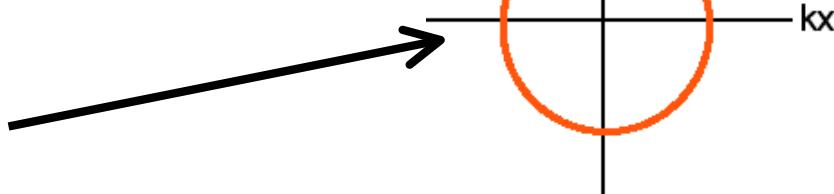
How to Suppress the Peierls Transition (in real space)

1. S → **Se** 1980 Bechgaard, Jerome

One-dimensional $(\text{TMTSF}^{0.5+})_2\text{X}$, X=ClO₄



2. S → **S + S**



3. **C₆₀** $(\text{M}^+)_3\text{C}_{60}^{3-}$, M=K, ...

1982 Two-dimensional Metal
no MI Transition
Saito, Enoki, Toriumi, Inokuchi

1991 Three-dimensional Metal
Hebard, Haddon et al.

Design of Functional Molecular Materials

Structure (Molecule, Crystal, Electronic, Band)

VS Function

Weak Intermolecular Interaction

CT (π - π , n- π), Hydrogen Bond($\text{CH} \cdots \text{O}$), vdW($\text{S} \cdots \text{S}$, $\text{Se} \cdots \text{Se}$, $\text{Te} \cdots \text{Te}$), Coulomb(Madelung, on-site off-site electron correlation)

CT:

e Donor + e Acceptor (or Anion)

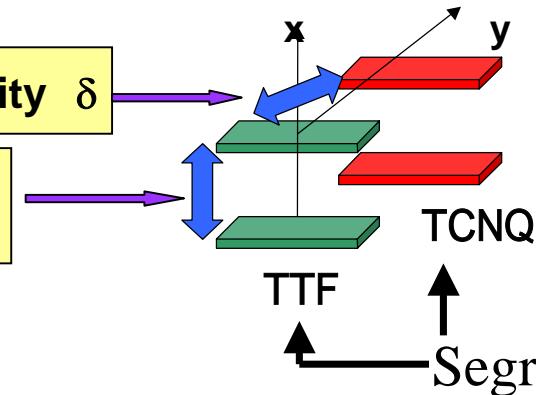
1) $\text{TTF}^{\delta+}\text{TCNQ}^{\delta-}$ ($\delta=0.59$)



CT₁ Control Ionicity δ

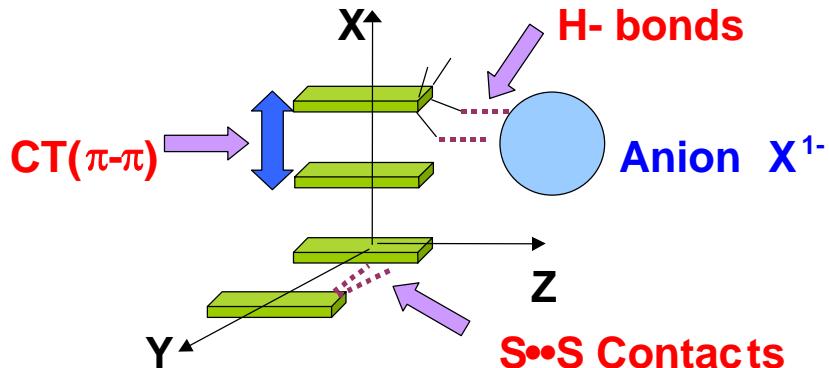
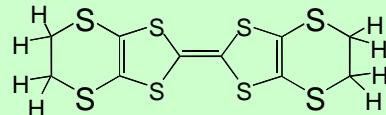
CT₂ Control Band, Fermi surface, ζ

$t_x \gg t_y, t_z \rightarrow 1\text{D metal}$



2) $(\text{BEDT-TTF}^{\delta+})_2X$

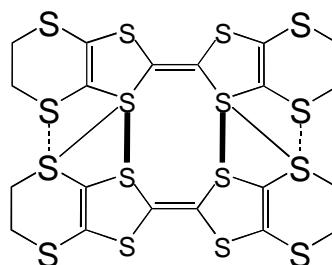
$\delta=0.5$ 1 hole / dimer



S···S Contacts

$$(\text{S}_{\text{in}} \cdots \text{S}_{\text{in}}) : (\text{S}_{\text{in}} \cdots \text{S}_{\text{out}}) : (\text{S}_{\text{out}} \cdots \text{S}_{\text{out}}) = 10 : 3.6 : 1$$

For ET salts: no $\text{S}_{\text{in}} \cdots \text{S}_{\text{in}}$ contact



$$t_x \sim t_y \gg t_z$$

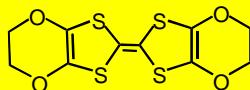
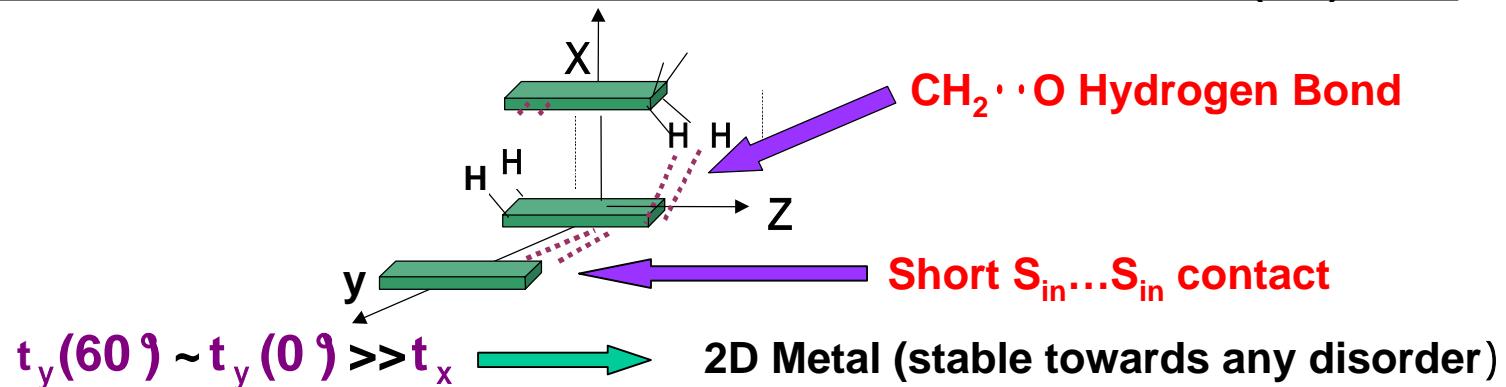
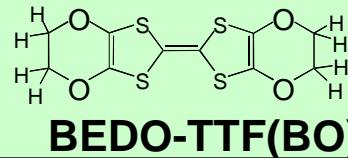
2 Dimensional

face-to-face ($\pi-\pi$) & side-by-side (S···S) compete
Hydrogen bond (CH-X) modifies electronic structure

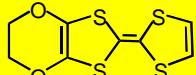
varied ethylene conformation

Polymorphism ($\alpha, \alpha', \beta, \beta', \beta'', \theta, \kappa \dots$)

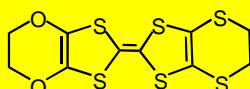
4) $(\text{BEDO-TTF})_2X$ Self-assembling Ability



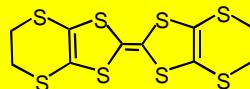
Metallic LB films, Metallic transparent films (self-assembling)



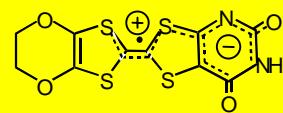
New Metal-Insulator Transition (molecular deformation)



Two-leg Spin-ladder (molecular symmetry C_{2v})



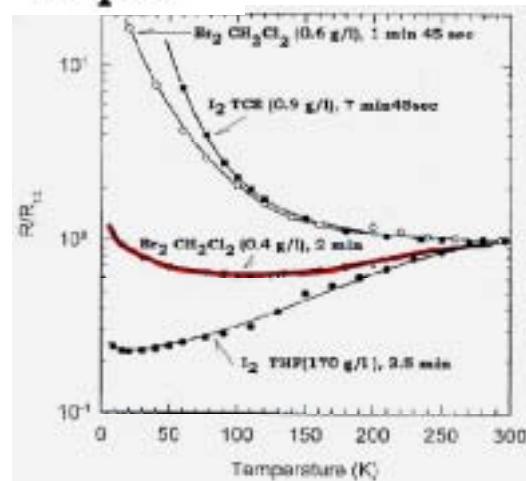
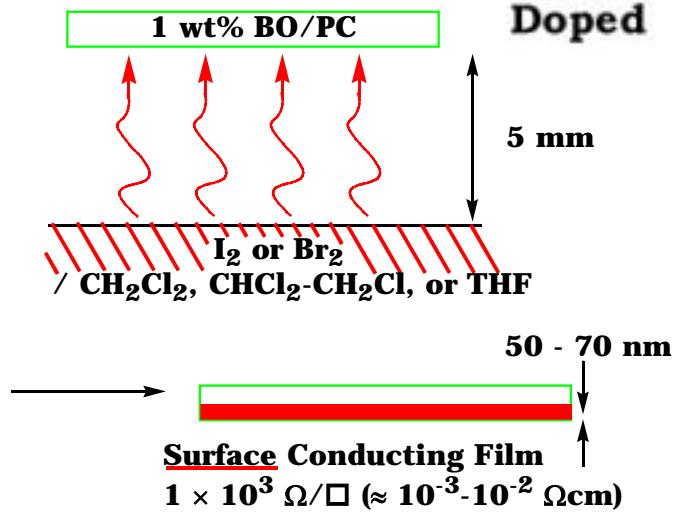
Spin-liquid vs Superconductor (e-correlation U/W , t'/t)



Molecular Electronics (mean free path vs e-correlation)

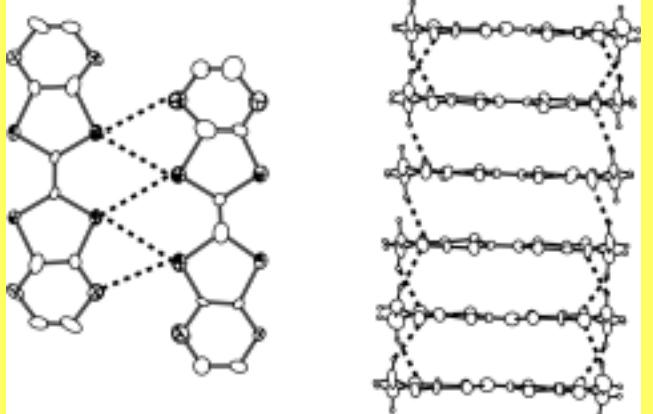


Film Preparation

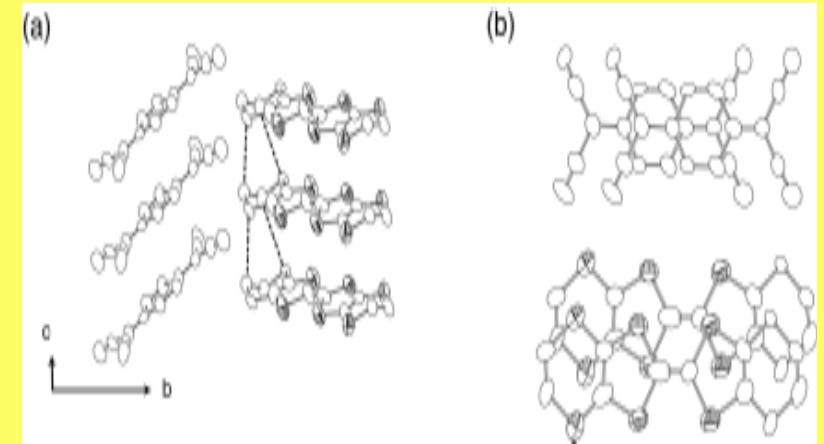


JMC 10, 893-910(2000) M(dto)₂, 10, 911-919(2000) TNBP, 11, 364-373(2001) DHCP, JACS 122, 4436-4442(2000) degree of CT, Synth. Metals, 120, 721, 739, 863 (2001) plasmons, design, MCLC, 376, 113-120(2002) MM'(ox)₃, JSSC, 168, 450-456(2002) M(isoq)₂(NCS)₄

Stacking of BO molecules

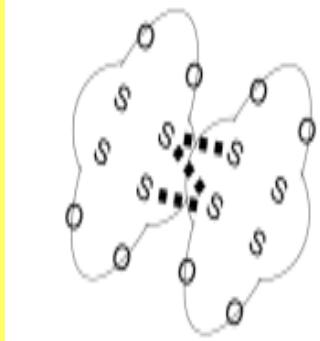


Stacking of EOET molecules

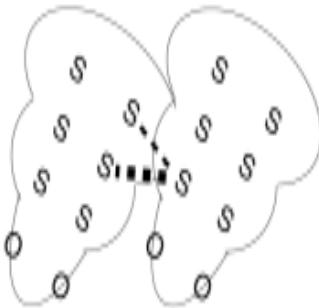


Geometry & Symmetry effect on side-by-side atomic contacts

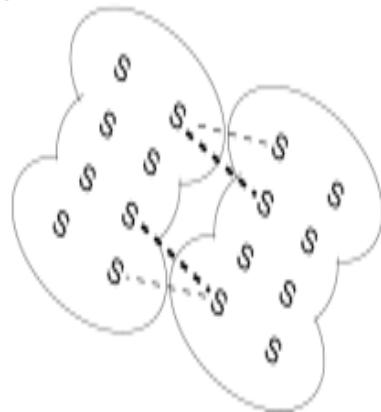
(a)



(b)



(c)



BO

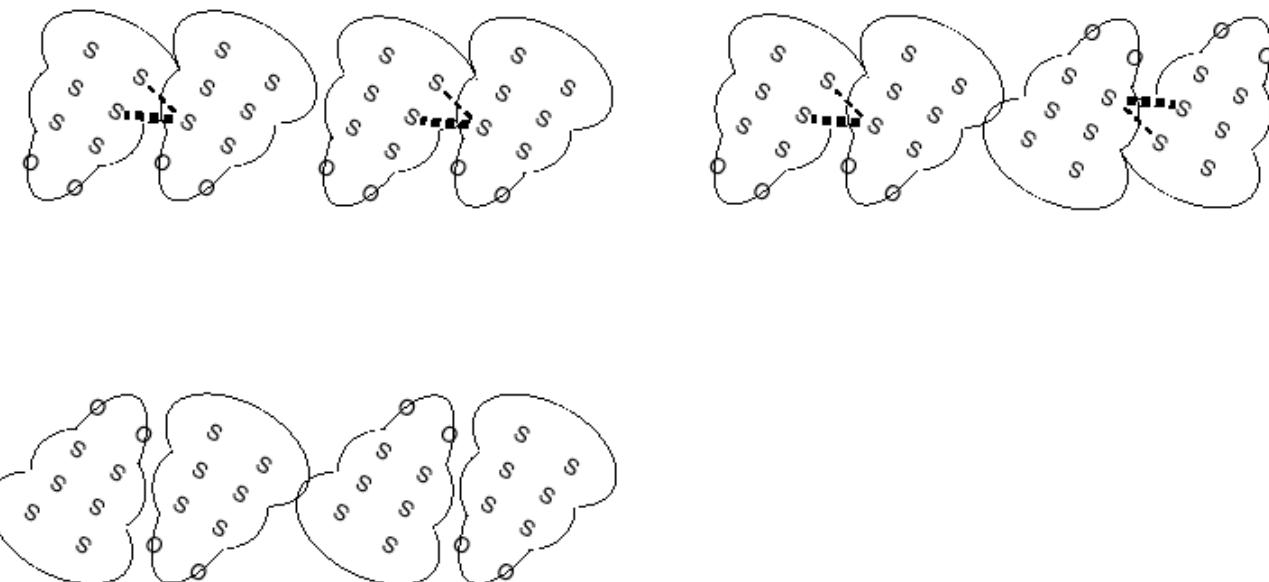
EOET(head-to-head)

ET

Design of Two-Leg Spin-Ladder based on EOET

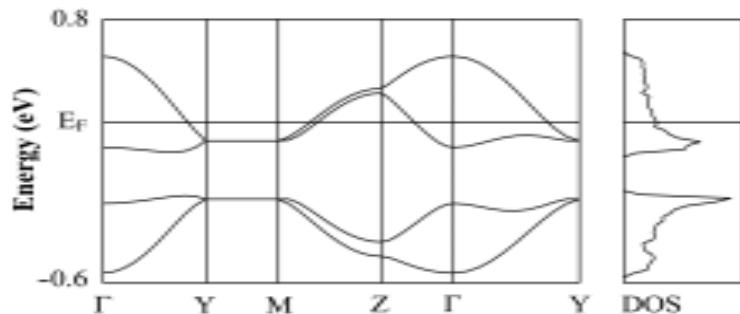
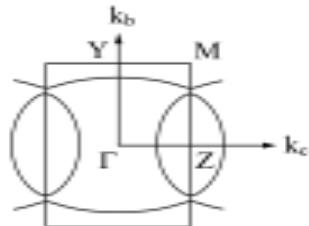
G. Saito et. al.

Figure 04

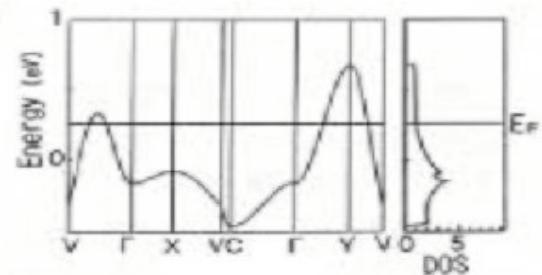
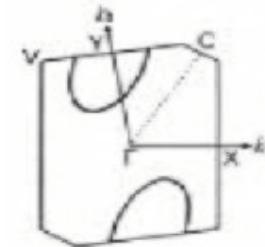


Energy Dispersion, Fermi Surface, DOS

κ -(ET)₂Cu(NCS)₂

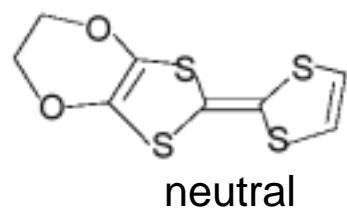
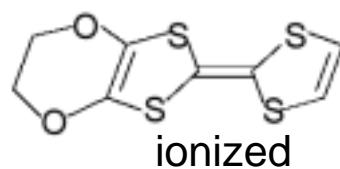
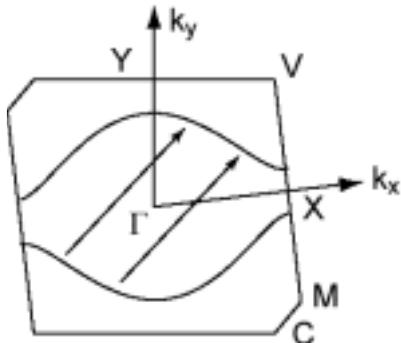


(BO)_{2.4}I₃



2D → 1D

(EDO)₂PF₆



New Metal-Insulator Transition triggered by molecular deformation

Ota, Yamochi, Saito
J. Mater. Chem., 12,
2600(2002)

Summary(1)

1. Uniform Segregated Column with Partial CT
controllable by Self-assembling Ability & ($I_P - E_A$)

2. Dimensionality

controllable by physical (pressure) & chemical
"heavy atom substitution" "peripheral addition
of alkylchalcogeno groups" methods

(size, symmetry, degeneracy)

1D TTF

1~2D ET

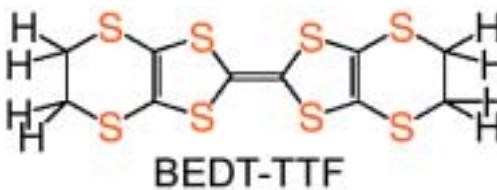
EOET

2D BO

Stability
&
Self-Assembling Ability

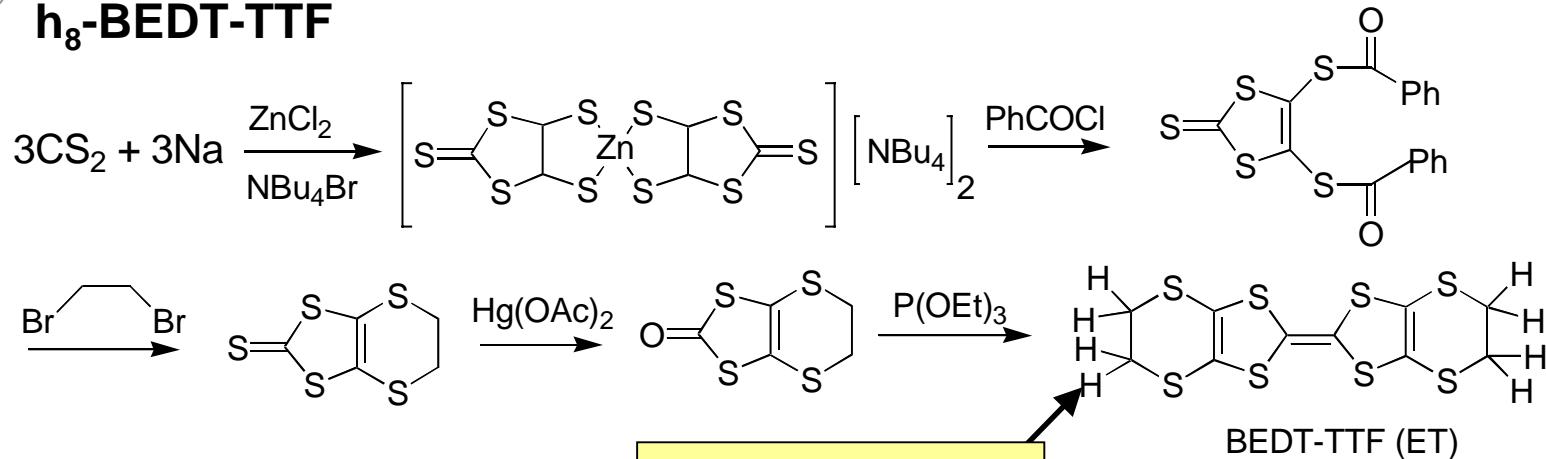
Preparation & Characterizations of 10 K Class Superconductors

	Tc/K	
	H	D
κ -(ET) ₂ Cu(NCS) ₂	10.4	11.2
Cu[N(CN) ₂]Br	11.8	11.2
Cu[N(CN) ₂]Cl	12.8	13.1 (at 0.3kbar)
Cu(CN)[N(CN) ₂]	11.2	12.3

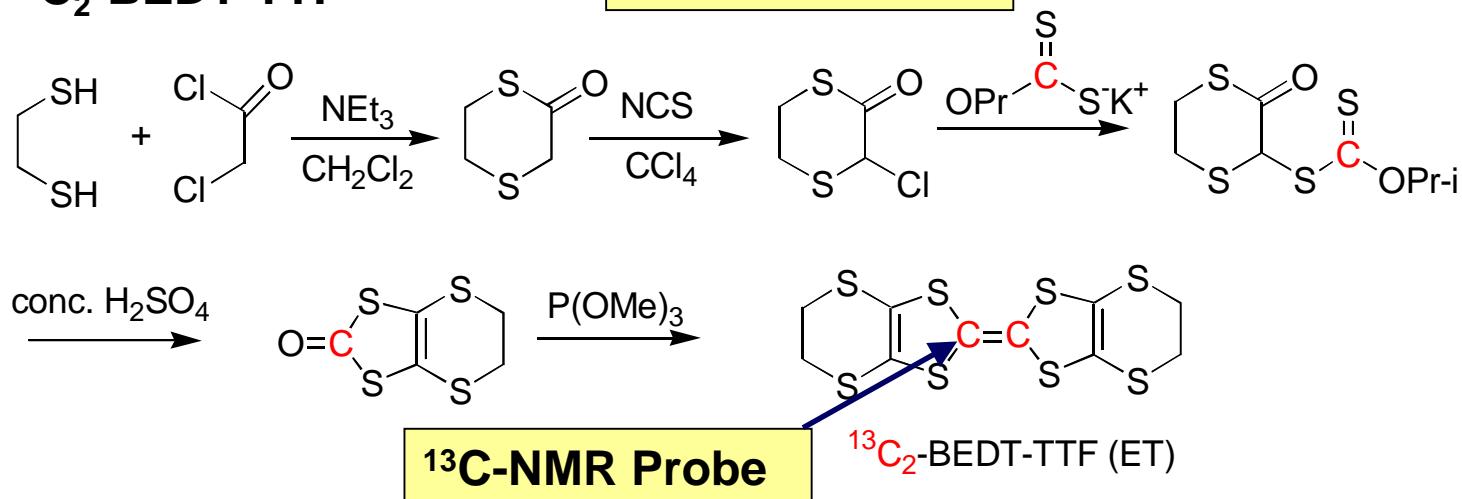


Synthesis of BEDT-TTF (ET)

h_8 -BEDT-TTF



$^{13}C_2$ -BEDT-TTF



Long Symmetric Linear Anion ?

NCS - Cu - SCN
~ 15 Å

vs

I - I - I⁻
10.1 Å β -(ET)₂I₃ Tc = 8K

Electrococrystallization

1. Supporting Electrolyte

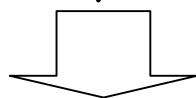
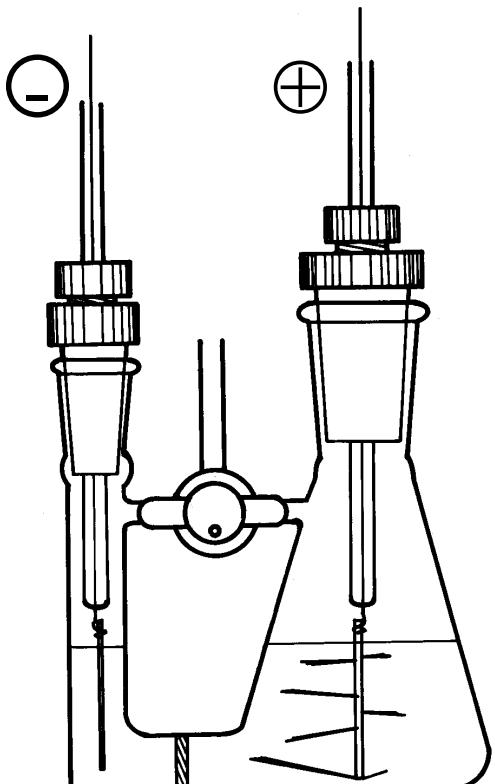
CuSCN + KSCN + 18 -crown-6 ether
70 mg 130 mg 200 mg



2. Donor $BEDT-TTF \longrightarrow BEDT-TTF^+$

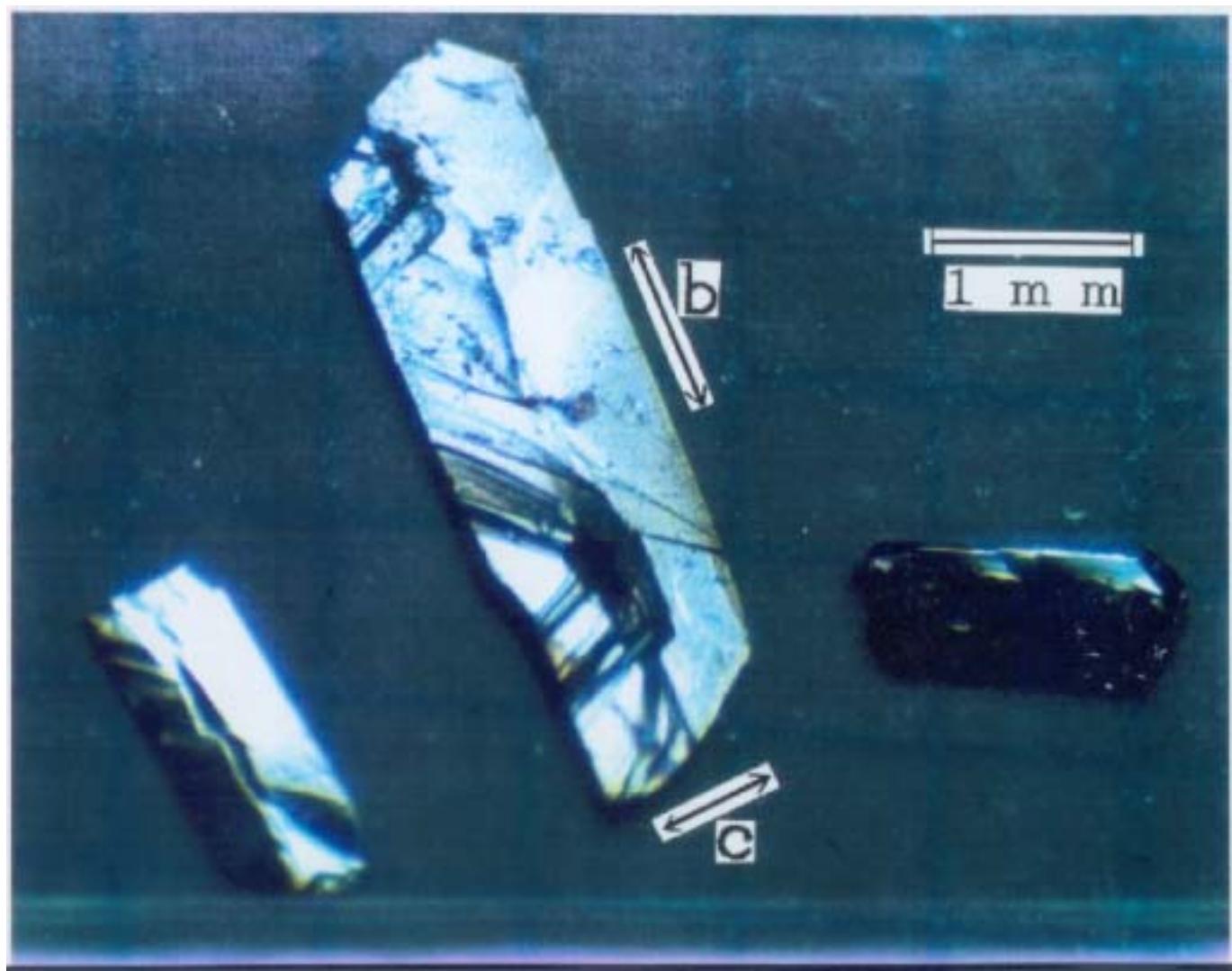
3. Solv 1,1,2-trichloroethane or benzonitrile

4. Current 0.5 ~ 4 μ A, ~2 weeks

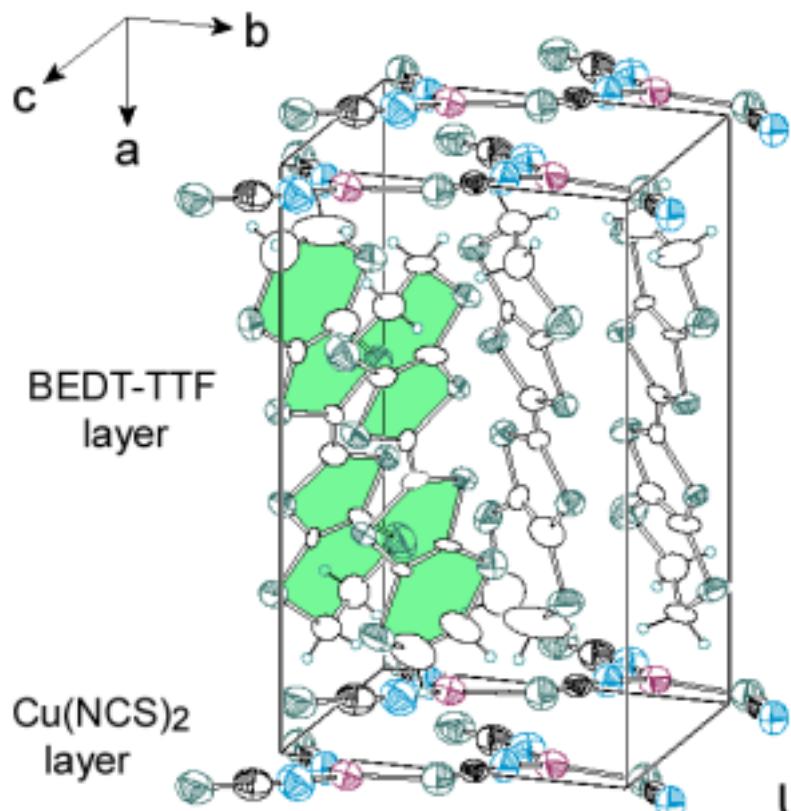


$(BEDT-TTF)_2Cu(NCS)_2$
1988 Urayama, Saito *et al.*

κ -(BEDT-TTF)₂Cu(NCS)₂ bc-plane: 2D conducting

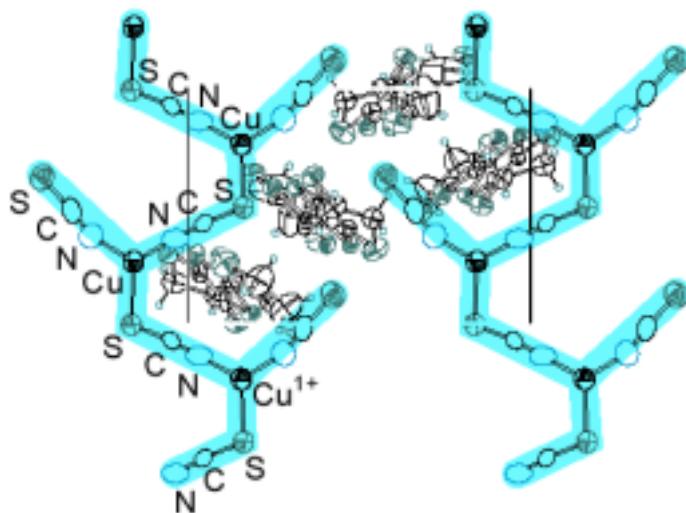


κ -(BEDT-TTF)₂Cu(NCS)₂



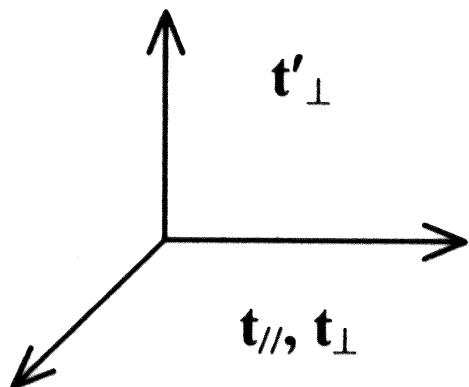
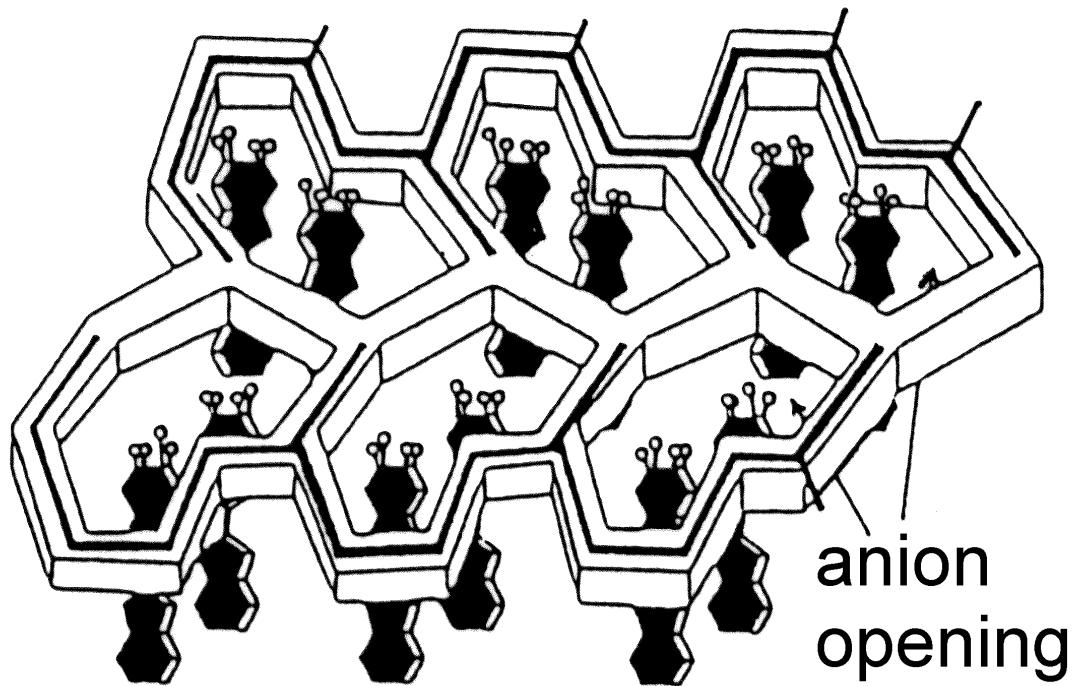
[dextro rotatory form]

monoclinic $P2_1$



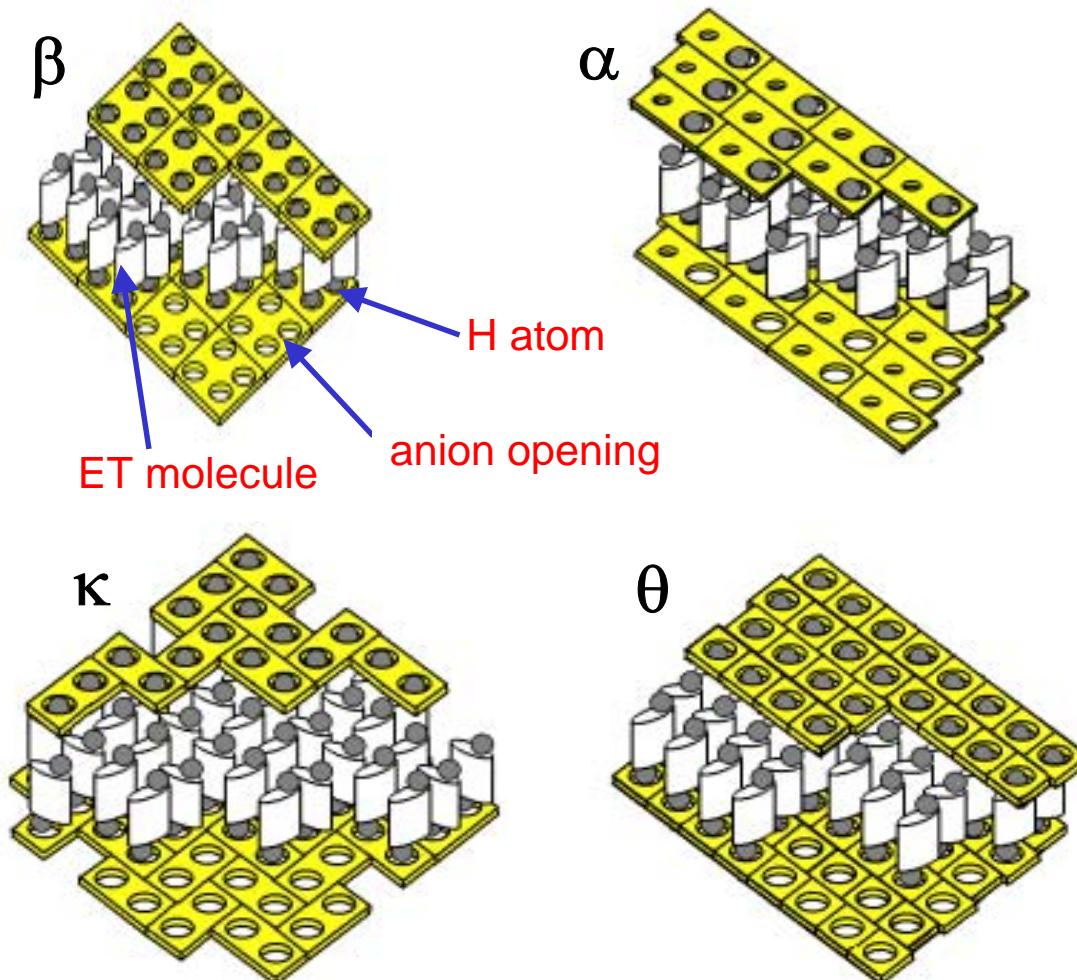
Urayama, Saito *et al.*,
Chem. Lett., 1988, 55

κ -(BEDT-TTF)₂X, X:polymerized anion



1. Pattern \longrightarrow donor packing pattern
2. Basal Plane Size \longrightarrow $t_{//}, t_\perp$, DOS
3. Thickness \longrightarrow t'_\perp

Patterns of Anion Opening & Donor Packing



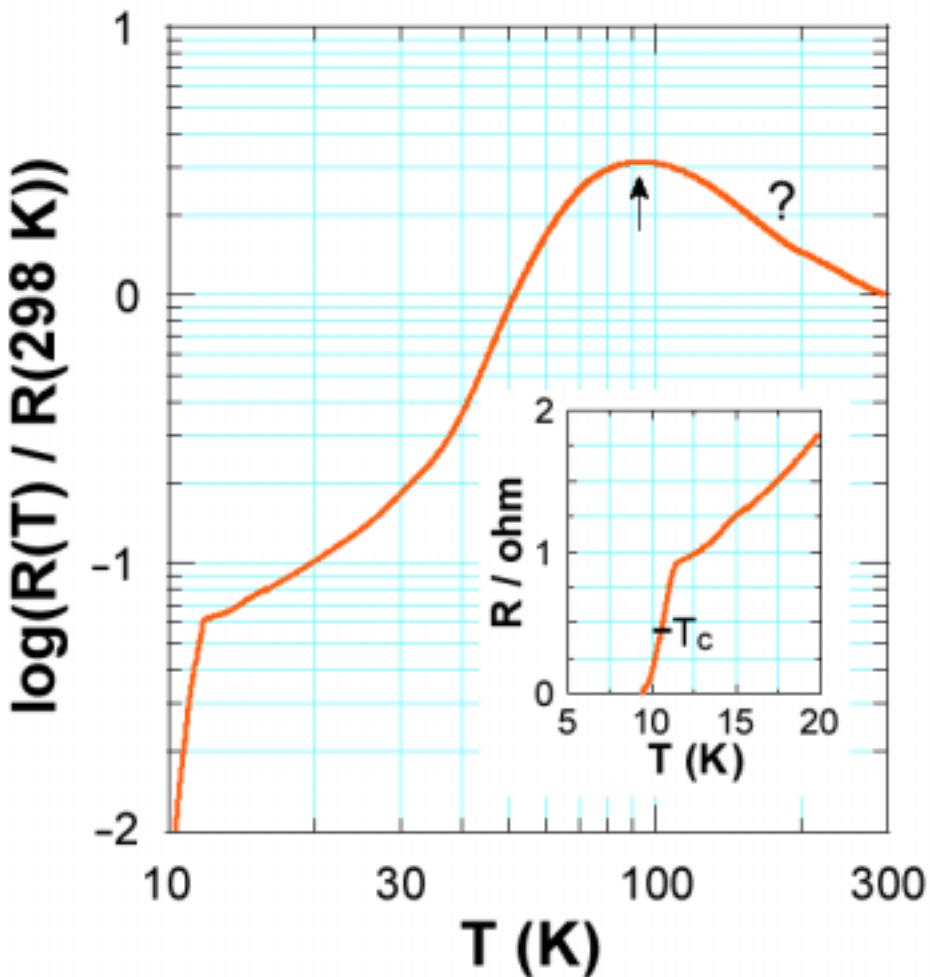
H.Yamochi et al., JACS, 115, 11319(1993)

Design of High T_c ET Superconductors

1. Big anion → Packing density of ET↓ → $t_{//}$ ↓ → DOS↑ → T_c ↑
 2. Thin anion → Inter-donor-layer t'_{\perp} ↑ → 3D nature↑ → T_c ↑
 3. 2D polymerized anion + donor-anion interaction↑
3D structural nature↑ → thermal contraction↓
keep DOS large → T_c ↑
- ↓

Use **big** and **thin** anion which forms **thin 2D anion layer**
and provides both
loose donor packing and **strong anion••donor atomic contacts**

κ -(BEDT-TTF)₂Cu(NCS)₂



4 probe Au wire Au paste

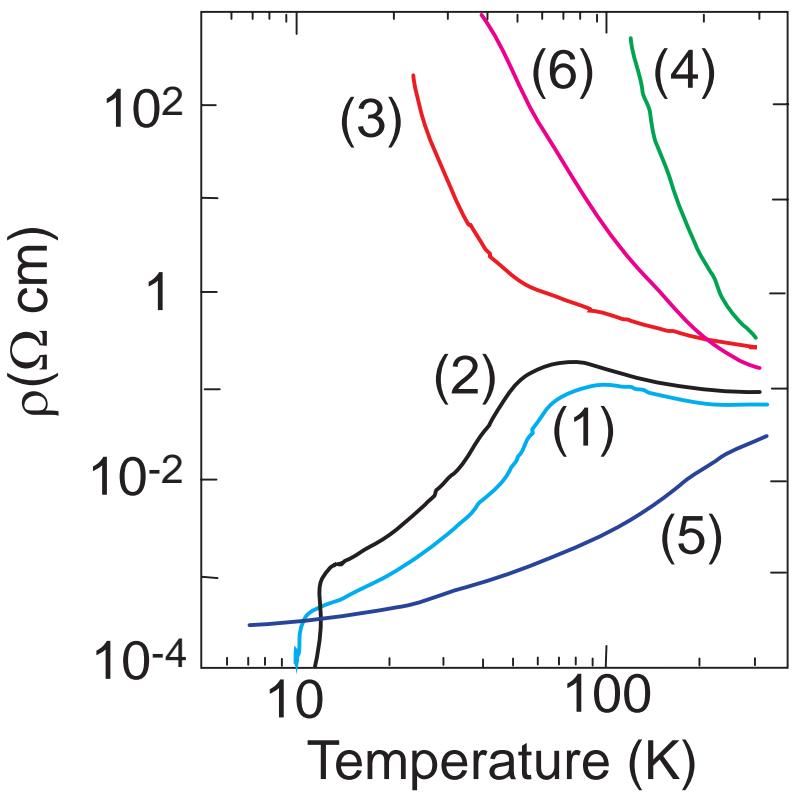
$$\sigma_{RT}(/b) = 10 \sim 40 \text{ S cm}^{-1}$$

$$\sigma_a^* : \sigma_b : \sigma_c = 1/600 : 1 : 1.2$$

T_c on set : 11.0 K
 off set : 9.8 K
 mid-point : 10.4 K

Pressure $\uparrow \rightarrow T_c \downarrow$
(-3.0 K/kbar)

Resistivity for ET Salts



10K Class Superconductor

- (1) $\kappa\text{-(ET)}_2\text{Cu(NCS)}_2$
- (2) $\kappa\text{-(ET)}_2\text{Cu[N(CN)}_2\text{]Br}$

(3) $\kappa\text{-(ET)}_2\text{Cu[N(CN)}_2\text{]Cl}$

Mott Insulator at Ambient
Superconductor at 0.3kbar

Electron Correlated Insulator

(4) $\theta\text{-(ET)}_2\text{Cu}_2(\text{CN})[\text{N(CN)}_2]_2$

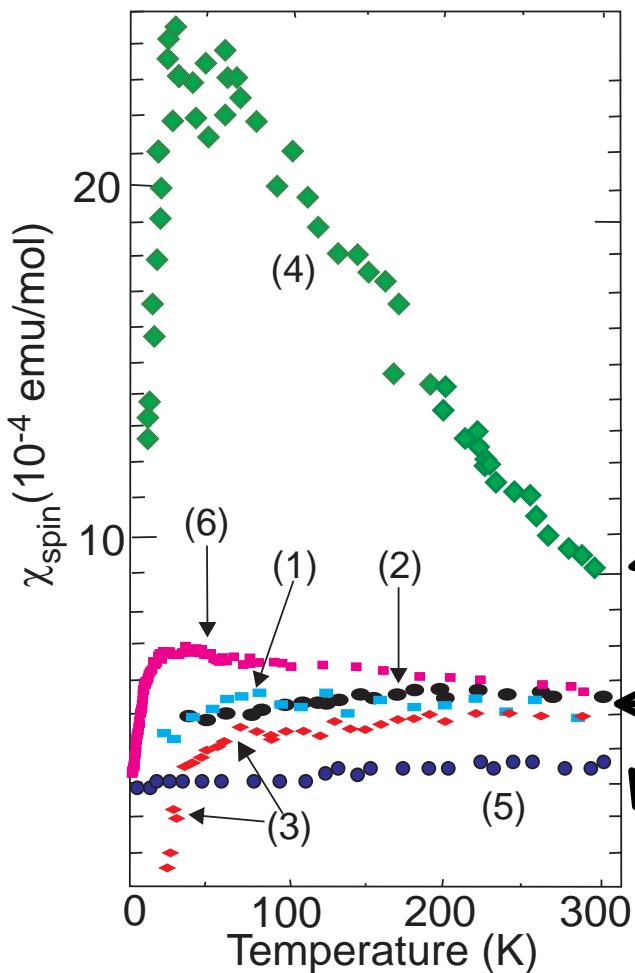
2D Metal with low Tc

(5) $\beta\text{-(ET)}_2\text{AuI}_2$

What about

(6) $\kappa\text{-(ET)}_2\text{Cu}_2(\text{CN})_3 \rightarrow$ Mott Insulator

EPR Magnetic Susceptibility χ_{spin}



For a metal $\chi_{\text{spin}} = \chi^0_{\text{spin}} / (1 - D(\varepsilon_F) U_{\text{eff}})$

χ^0_{spin} : Pauli Paramagnetism

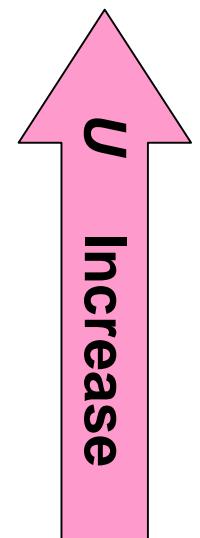
$D(\varepsilon_F)$: Density of States at Fermi level

U_{eff} : effective U

Insulator:(4)

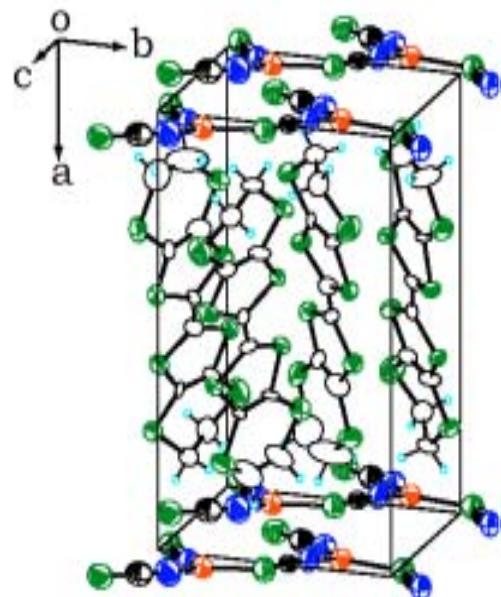
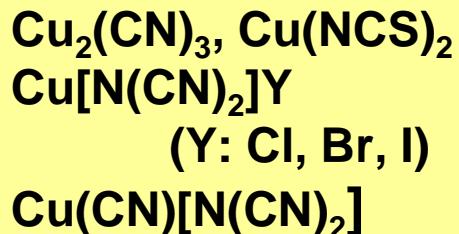
10K Super (Poor Metal)
(1), (2), (3) & (6)?

Good Metal: (5) $\beta-(ET)_2AuI_2$

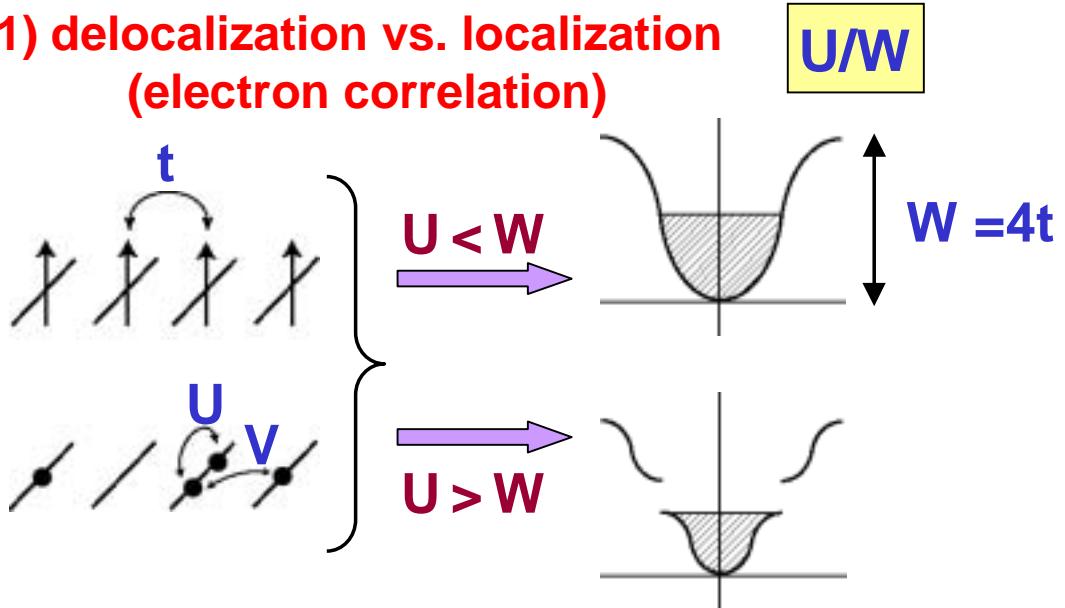


κ -Type 10 K Superconductor κ -(ET)₂X

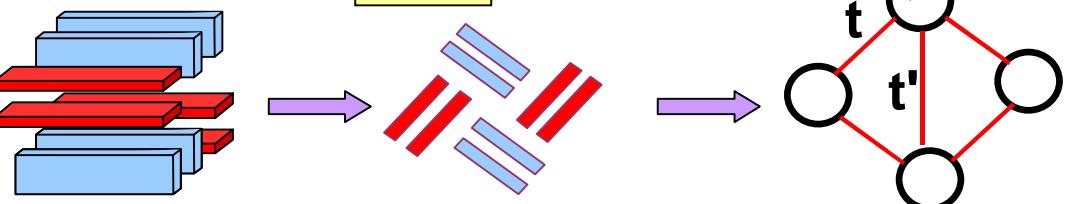
X: polymerized anion



1) delocalization vs. localization
(electron correlation)



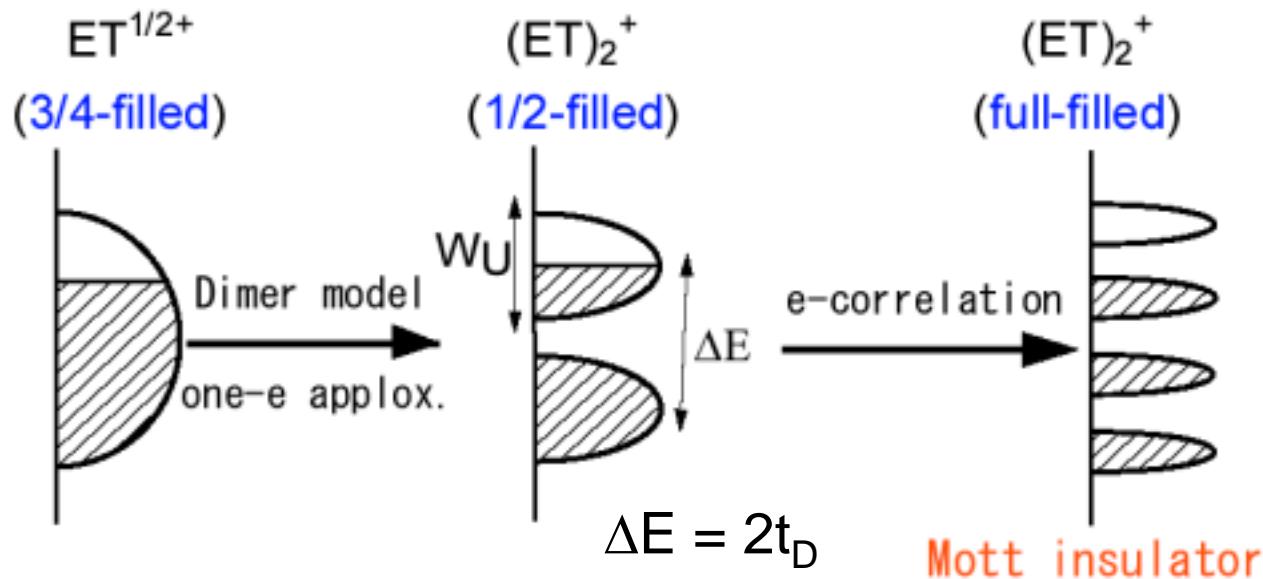
2) anisotropy



Electron correlation

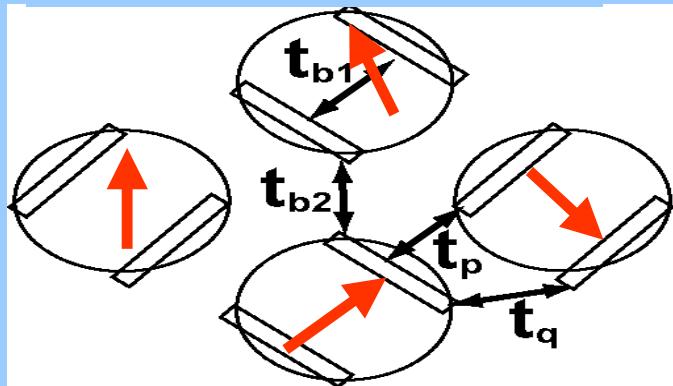
Mott criterion for dimerized system: $W_u/\Delta E$ vs W_u

W_u : upper Hubbard band width, ΔE : dimerization energy



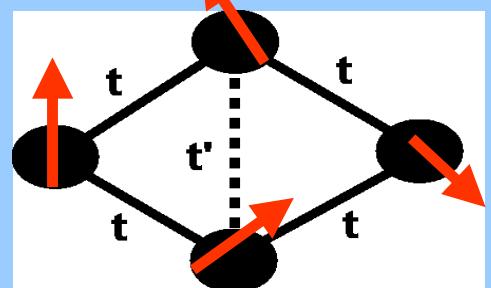
Anisotropy κ - $(ET)_2X$ = *anisotropic triangular lattice*
ET molecule = +0.5 \longrightarrow ET dimer has 1 spin

Donor Packing Pattern



dimer model

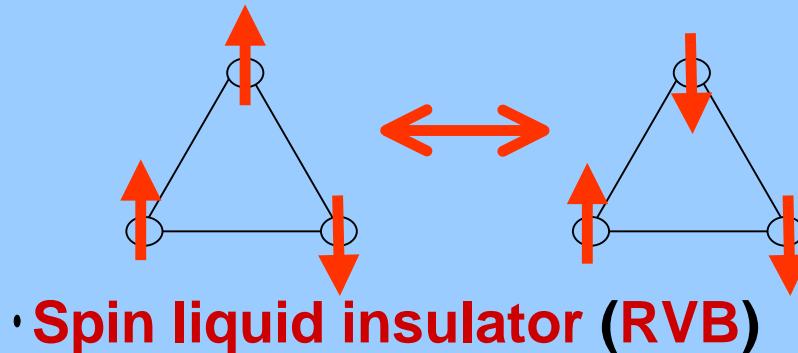
Triangular Spin Lattice



Large geometrical frustration between local spins when
 $t'/t \sim 1$

Ground state?

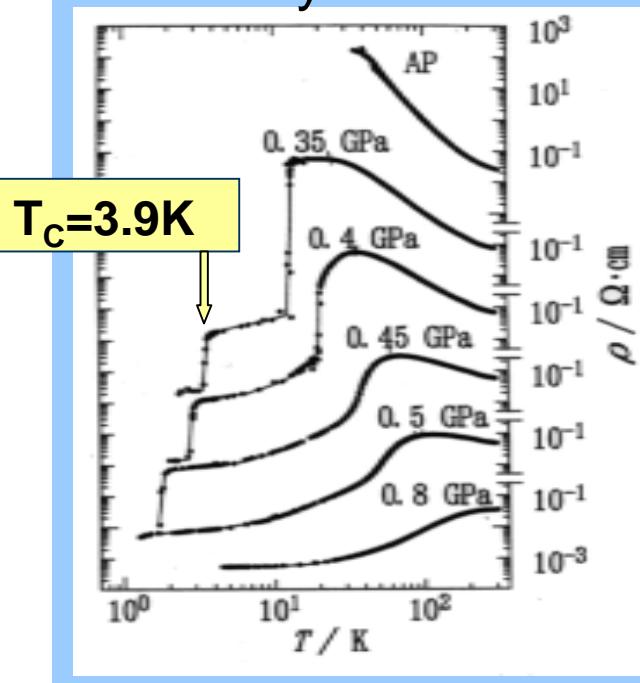
• Antiferromagnet



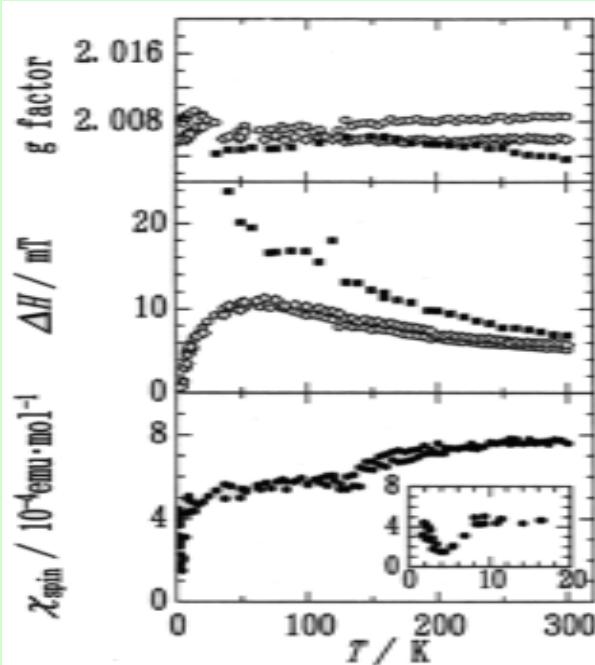
• Spin liquid insulator (RVB)

κ -(ET)₂Cu₂(CN)₃ Uniform triangular lattice → Ground state ?

Resistivity



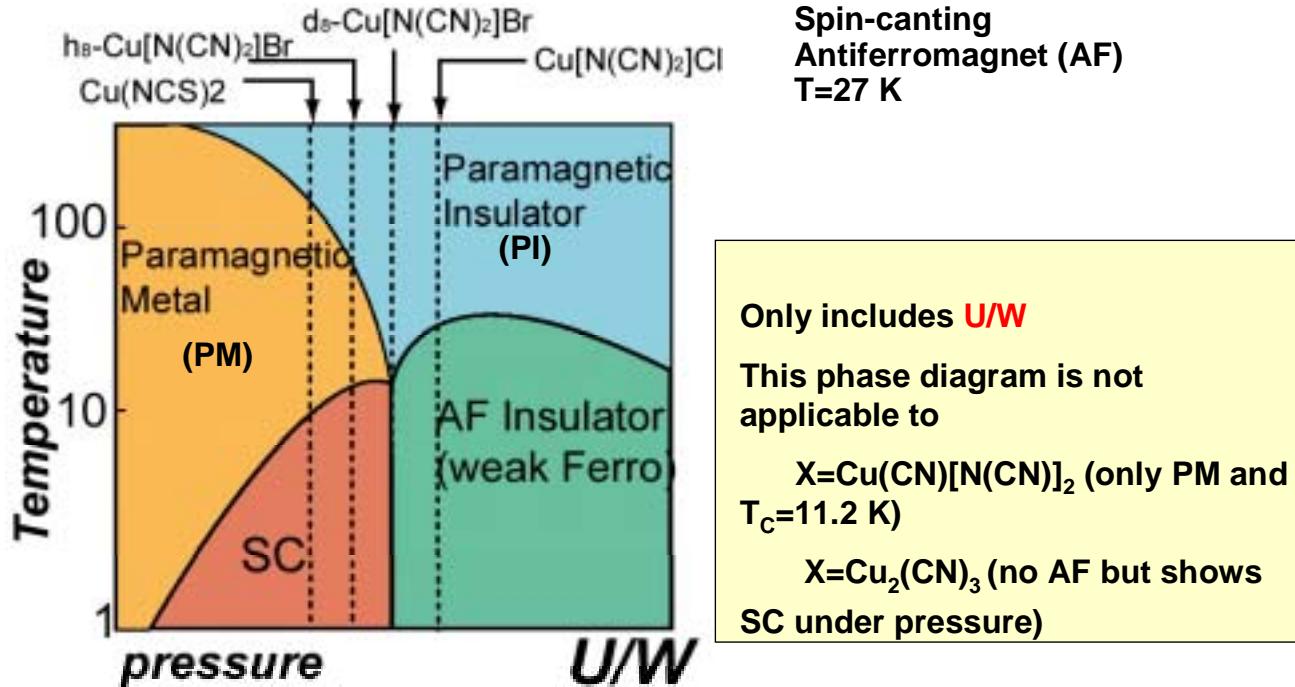
EPR



X	t'/t	ground state	Tc (K)	Pc(kbar)
$\text{Cu}_2(\text{CN})_3$	1.06	???	3.9	0.4
$\text{Cu}[\text{N}(\text{CN})_2]\text{Cl}$	0.75	Antiferro	12.8	0.3
d8- $\text{Cu}[\text{N}(\text{CN})_2]\text{Br}$	0.68	Antiferro		Rapid cool

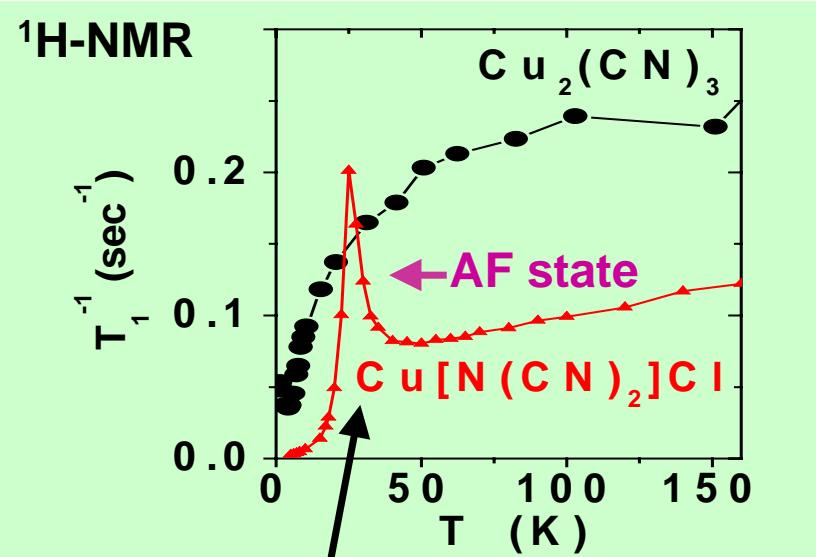
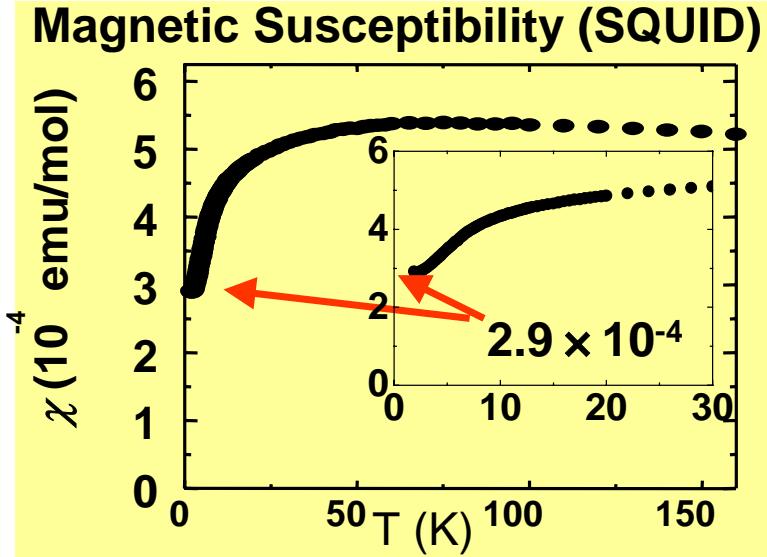
T. Komatsu et al. JPSJ (1996), McKenzie, Comm. Cond. Mat. Phys. (1998)

κ - $(ET)_2X$ T - P phase diagram



K.Kanoda 1997

Ground State of a Mott Insulator κ -(ET)₂Cu₂(CN)₃



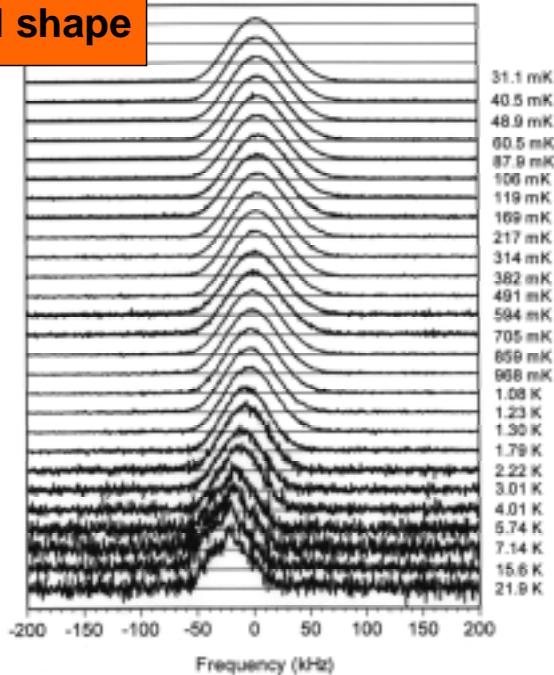
- ¹H-NMR $\sim 31 \text{ mK}$
- SQUID $\sim 1.9 \text{ K}, 0.32 \text{ T}$
- EPR $\sim 1.4 \text{ K}$
- μSR $1.5 \text{ K} - 20 \text{ mK}$

t'/t	G state
$\text{Cu}[\text{N}(\text{CN})_2]\text{Cl}$	$0.75 \quad \text{AF}$
(AF neighbors to SC state)	
$\text{Cu}_2(\text{CN})_3$	1.06

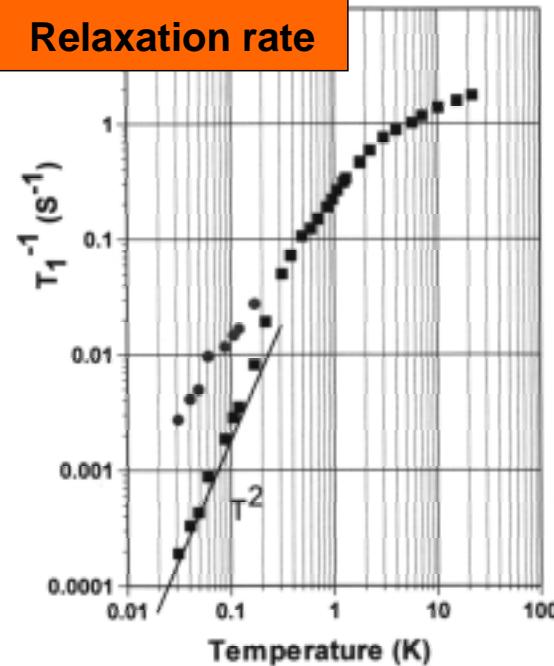
→ No Magnetic Order → **Spin-Liquid State**

Very resent results $^1\text{H-NMR}$
 (single crystal, $f_0=76.700$ MHz, $H_0=1.7967$ T 2D layer)

Signal shape



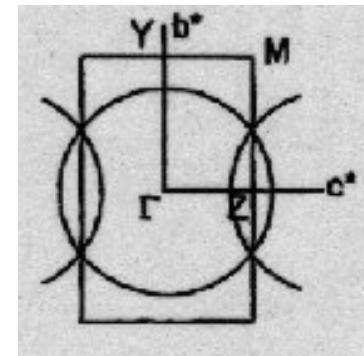
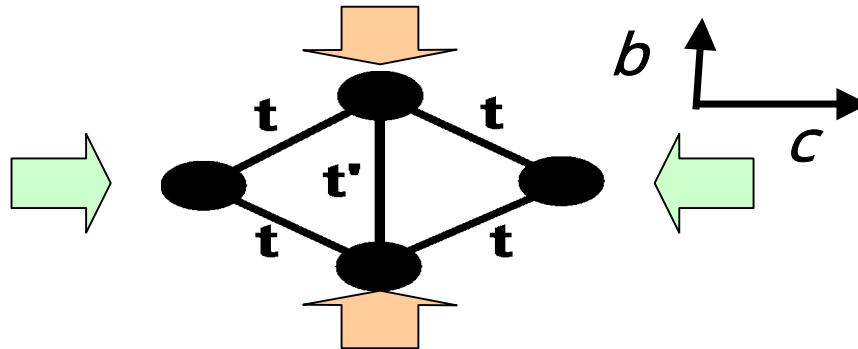
Relaxation rate



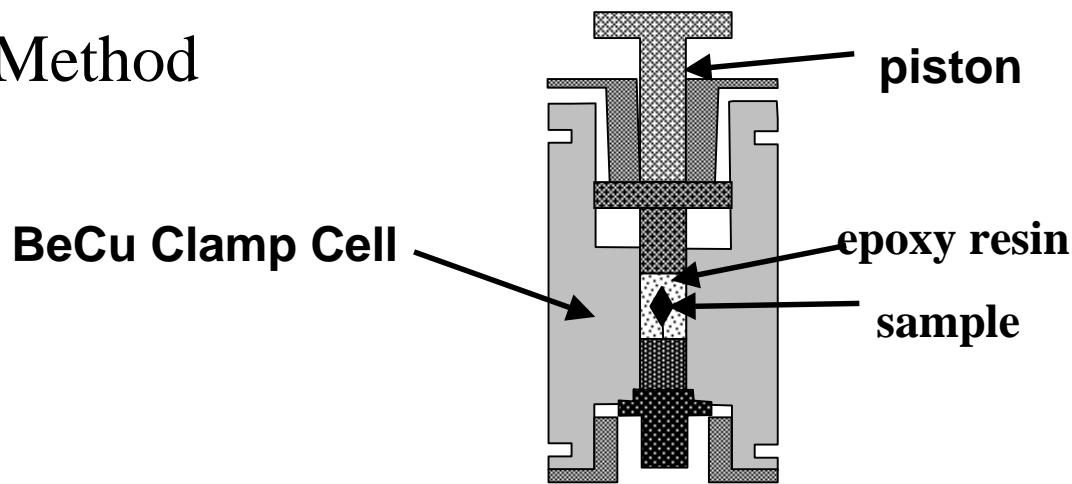
No Magnetic Order down to 30mK \longrightarrow spin-liquid state

Main signal () $T_1^{-1} \sim T^2$ \longrightarrow Gapless

Control of Triangular Anisotropy t'/t by Uniaxial Strain

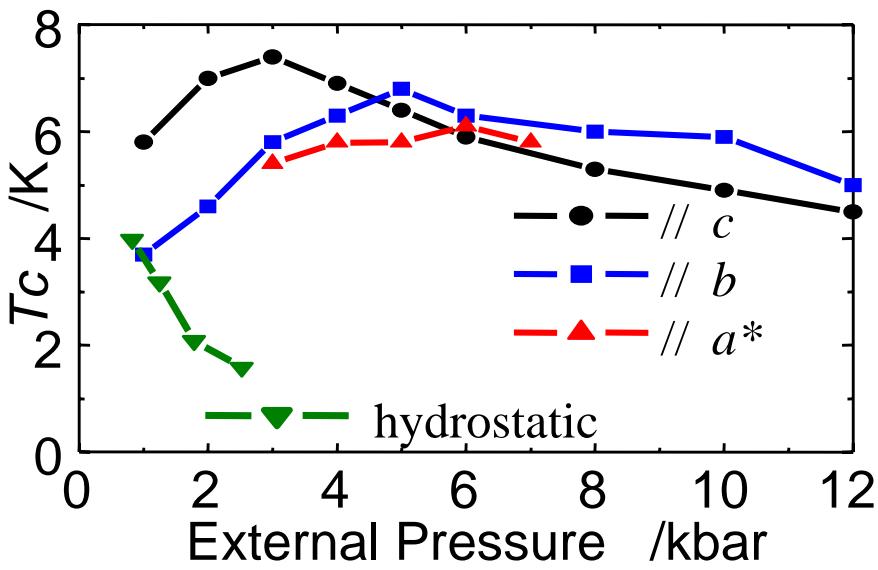
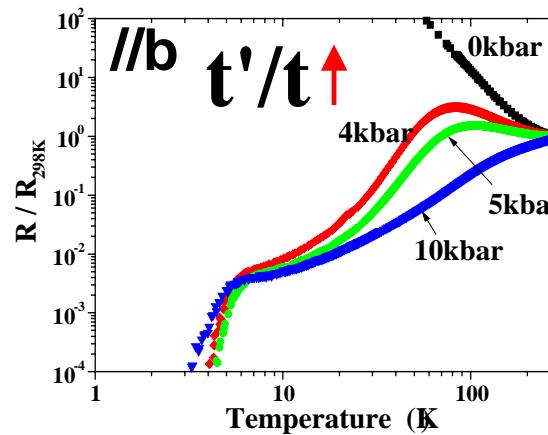
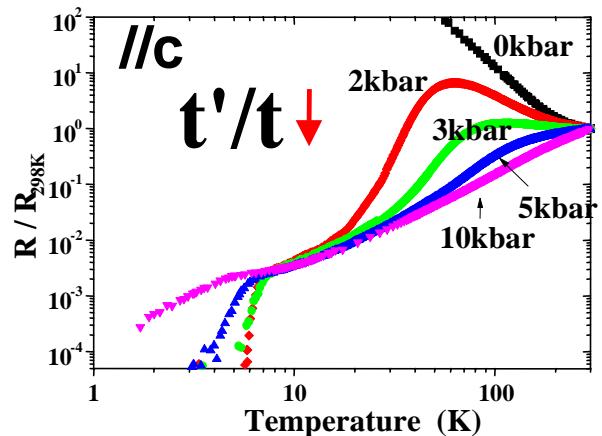


Maesato Method



Apply Stress Uniaxially without Poisson Effect

κ -(ET)₂Cu₂(CN)₃ Uniaxial Strain vs Hydrostatic Pressure



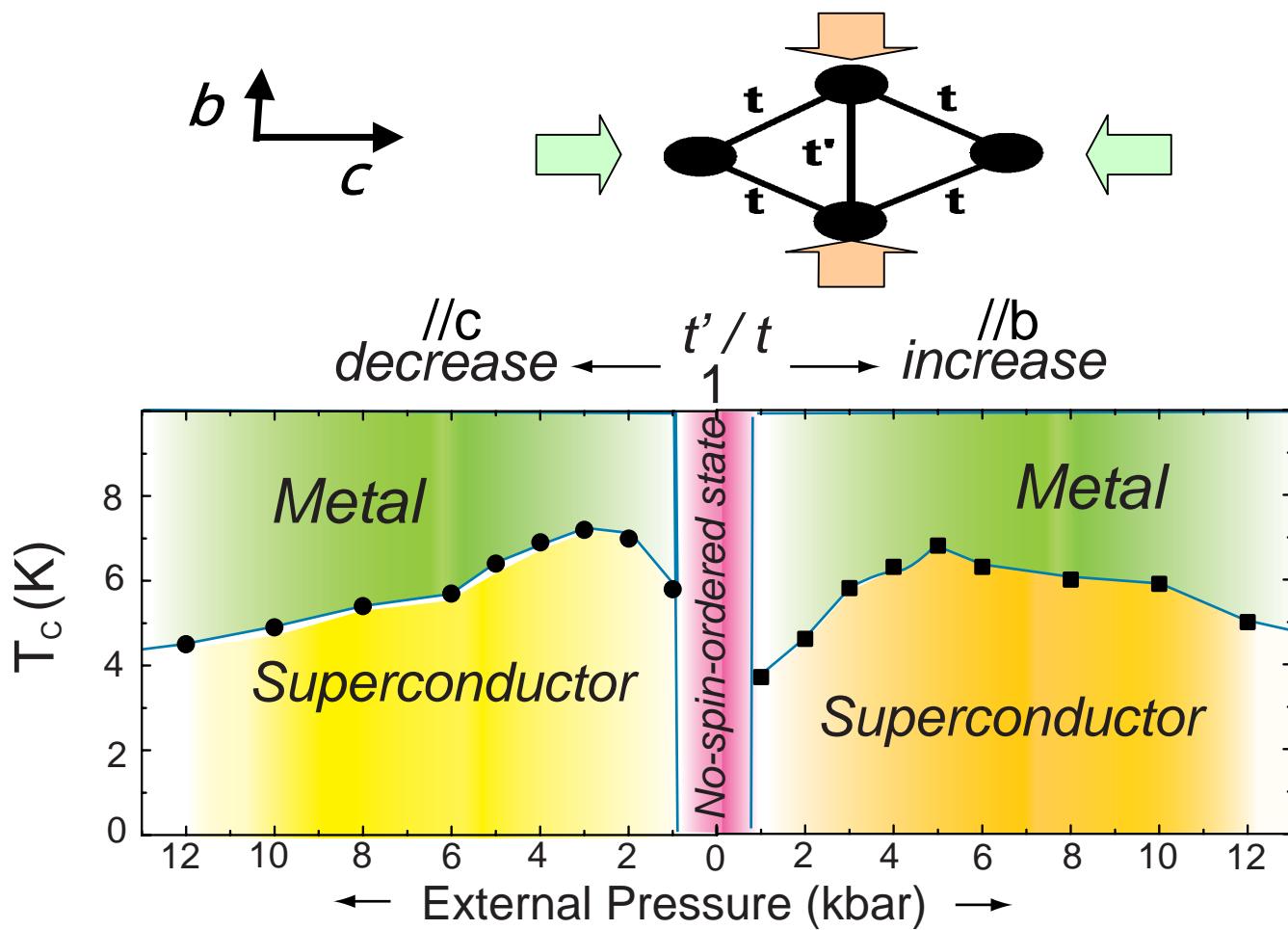
T_C under Uniaxial Strain

Increase in weak pressure in every direction

Anisotropic ($\|c > \|b > \|a^*$)

Higher than under hydrostatic pressure

Uniaxial Strain on κ -(ET)₂Cu₂(CN)₃



Summary(2)

1. Ground state of a Mott insulator κ -(ET)₂Cu₂(CN)₃ is **Spin-Liquid State**

2. Anisotropy t'/t is critical for ground state of κ -(ET)₂X: spin-ordered AF vs. spin-disordered (spin-liquid) states

3. **Uniaxial Strain** vs ~~Hydrostatic~~ for Anisotropic Electronic State

A release of spin frustration in a spin-liquid state induces a superconducting state



Magnetic mediation

Molecular Design of Single Component Conductors

NATO

1. Introduction

Examples of Single Component Conductors

- a. Super under Pressure
- b. Organometallic complexes
- c. Neutral Closed Shell Compounds
- d. Neutral Open Shell Compounds
- e. Zwitter ionic (Betainic) Radicals

2. On-Site Coulomb Repulsion

vs Mean-Free Path of Molecular Wire

3. Fused Mesomeric Betainic Radicals

4. Hydrogen Bond & Self-Complementarity

Many electrons in **nano-scale stage**
made of **soft & anisotropic media**

*molecular engineering,
pressure, doping*

